

OPCB

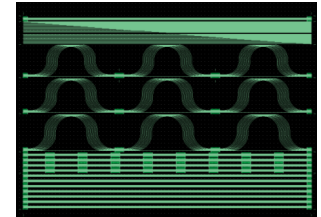
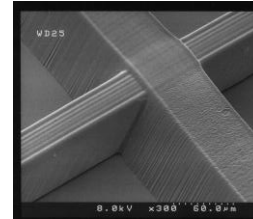
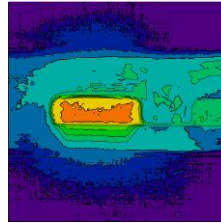
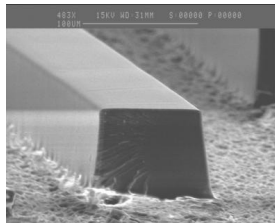
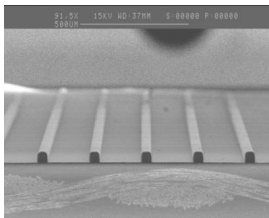
INTEGRATED OPTICAL AND ELECTRONIC INTERCONNECT PCB MANUFACTURING (OPCB)

IeMRC FLAGSHIP PROJECT

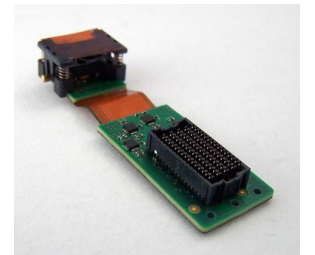
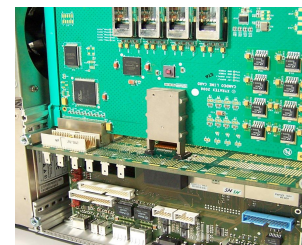
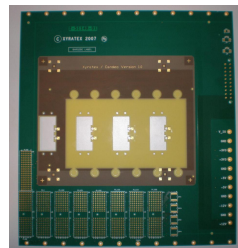
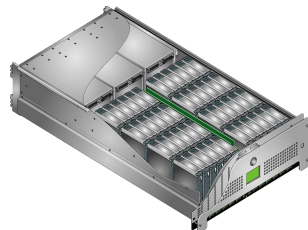
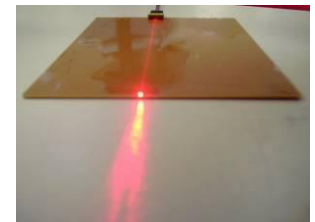


IeMRC Annual Conference
Loughborough

4th July 2008

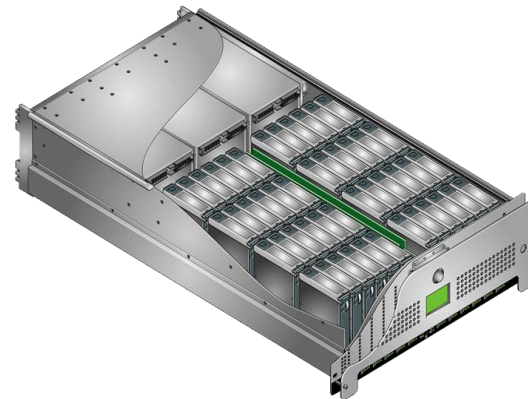
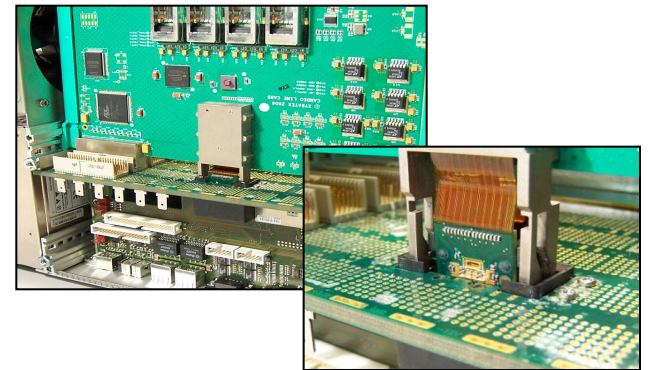
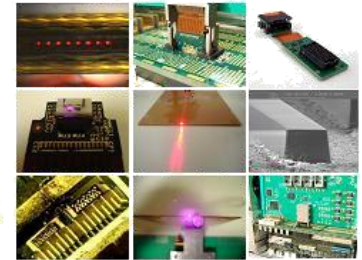
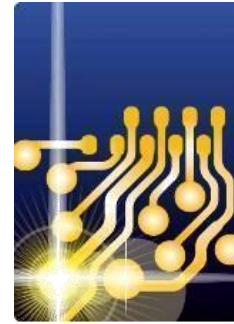


1. Enhance fabrication techniques for optical waveguides
2. Integrate optical layers into Printed Circuit Boards (PCBs)
3. Develop technology enablers: Connectors, CAD, Design Rules
4. Deploy Electro-Optical PCBs into end-user applications



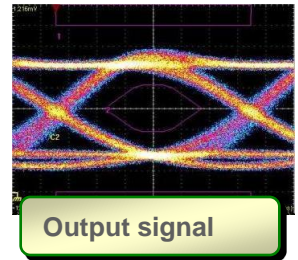
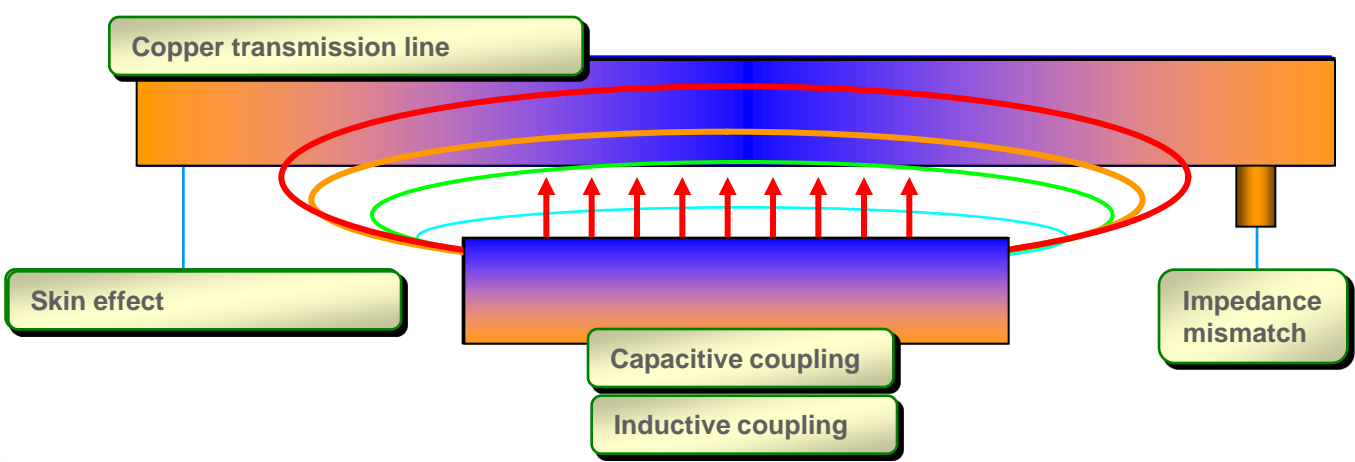
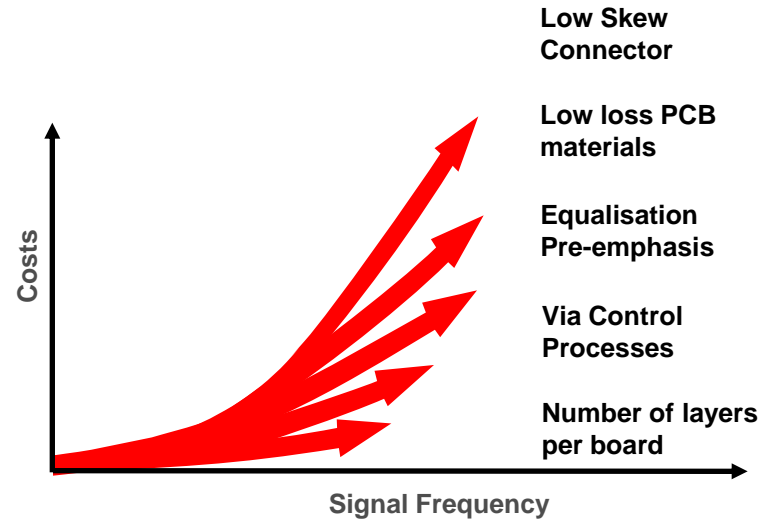
Research Objectives

- ❑ Investigate optical PCB technology
- ❑ Identify technology challenges
- ❑ Develop optical PCB and connector technology
- ❑ Integrate OPCB backplanes into storage systems
- ❑ Aid commercial proliferation

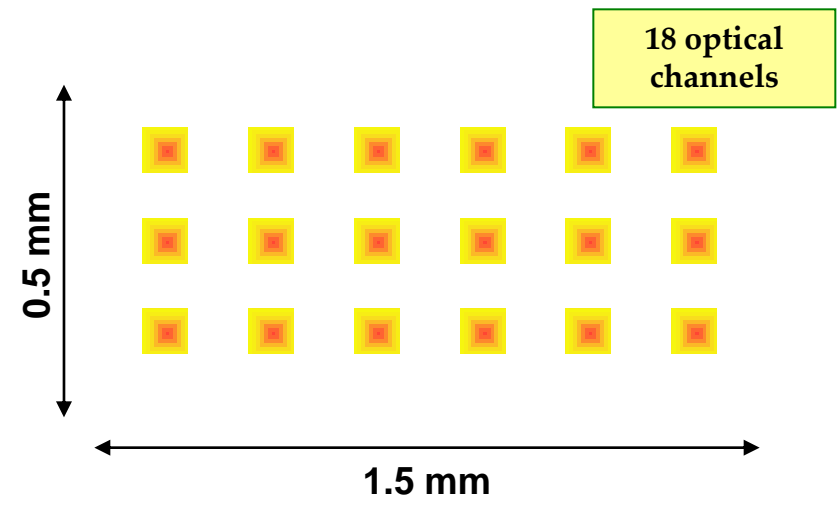
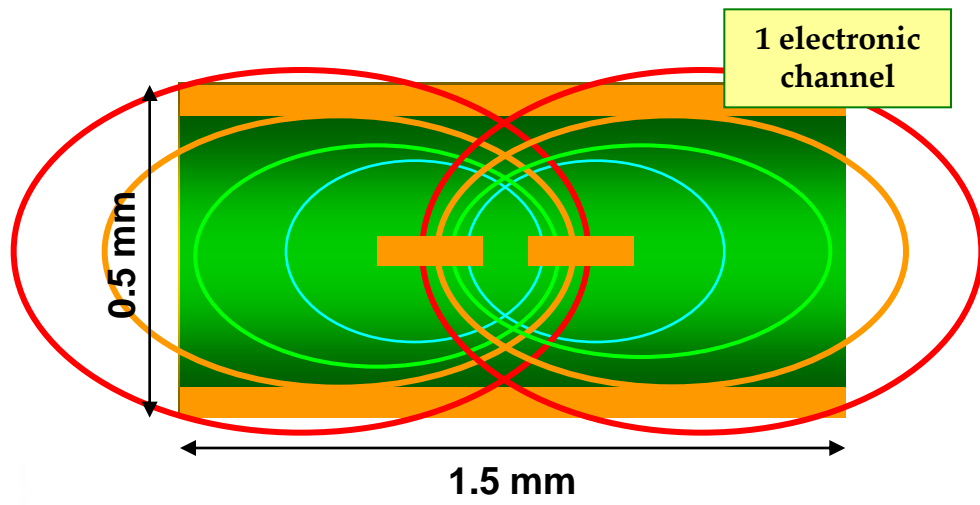
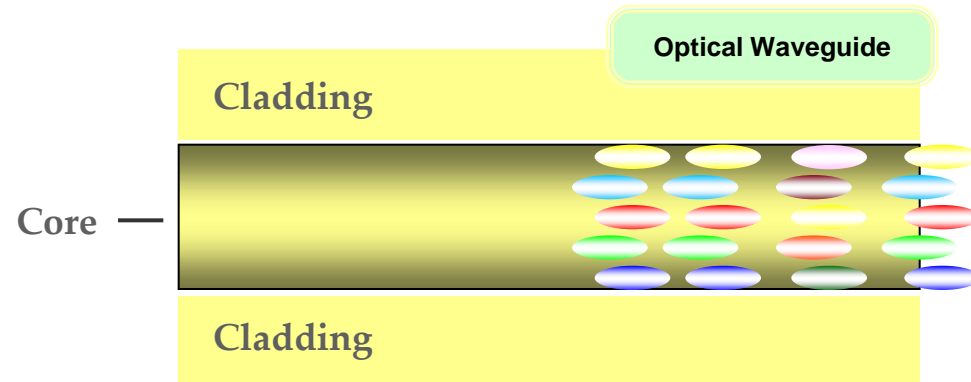


High frequency copper issues

- Crosstalk
- Reflections
- Electromagnetic Interference (EMI)
- Dielectric Loss / Skin effect
- Skew



- ❑ Optical signal pipelines possible
- ❑ Send optical data further
- ❑ Fit more optical channels
- ❑ Send data faster
- ❑ No EMI outside the waveguide
- ❑ Send multiple signals (WDM)



Data storage systems increasing in complexity, density and speed

Storage demand increasing

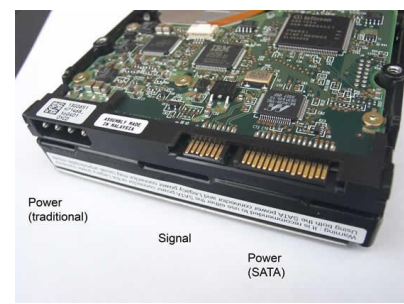
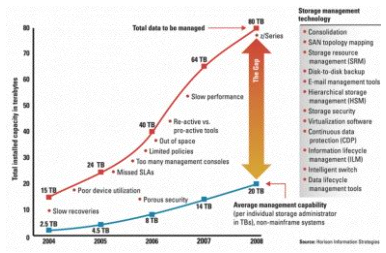
- Manage more storage
- Increased complexity

Disk sizes decreasing

- Increased system density

Data rates increasing

- Data access speeds:
 - 3 Gb/s SAS -> 6 Gb/s SAS
 - 10 Gb/s Gigabit Ethernet
 - 12 Gb/s SAS



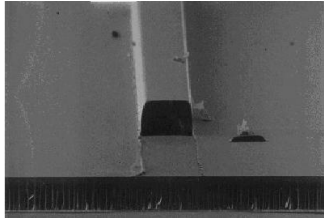
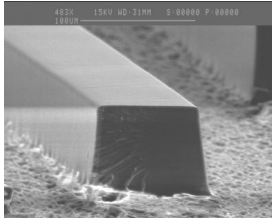
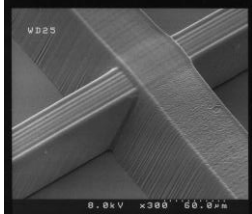
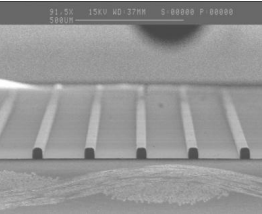
Two different classes of optical polymer evaluated and compared for waveguide production

Polyacrylates

Polysiloxane

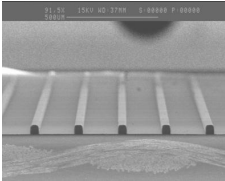
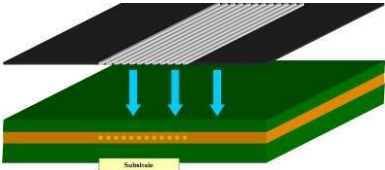
- ❑ Truemode® polymer - Exxelis
- ❑ New polymer formulations - Heriot Watt U

- ❑ Polysiloxane formulations – Dow Corning

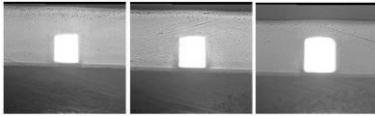
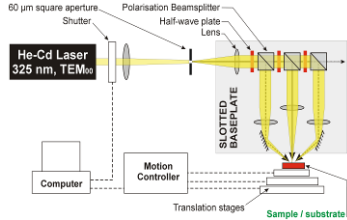


Four techniques for fabricating optical waveguides investigated and characterised

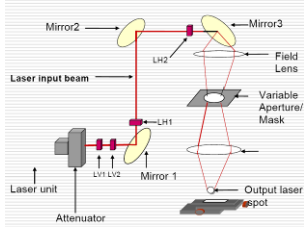
Photolithography



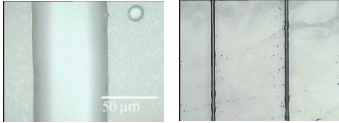
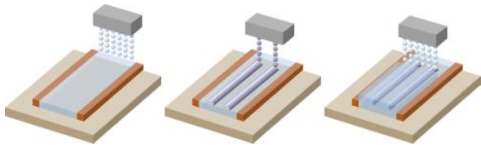
Laser Writing



Laser Ablation



Ink Jet Printing



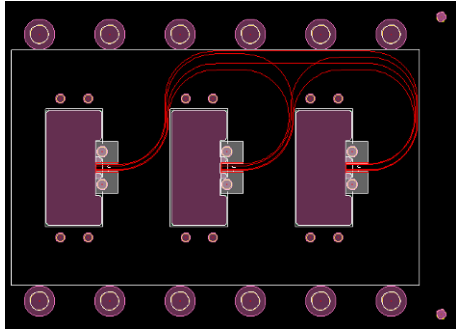
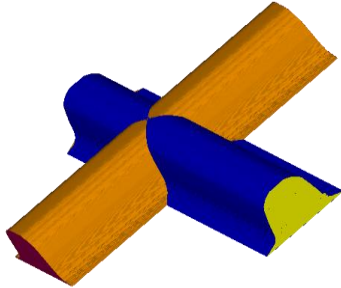
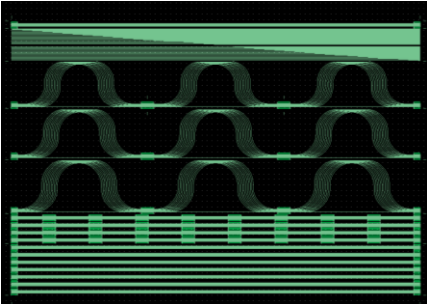
Design services for optical waveguide layout developed

Design Rules and Characterisation

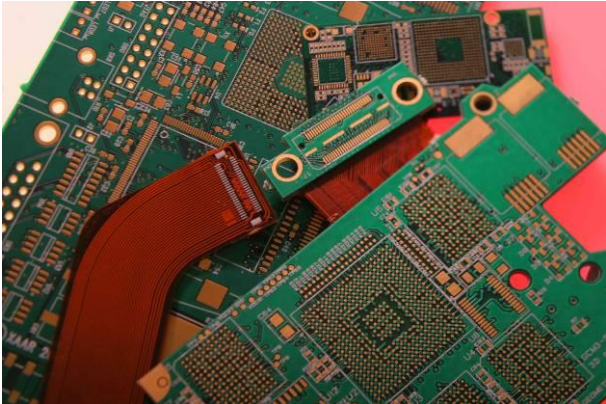
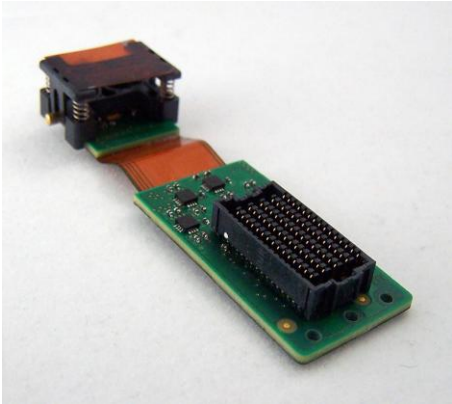
OPCB CAD Design

- ❑ PCB layout constraints for waveguides:
 - ❑ *Minimum bend radius*
 - ❑ *Separation*
 - ❑ *Crossing angle*

- ❑ Cadence software adapted to layout optical tracks
- ❑ Software used to design optical backplane



PCB Manufacturer to adapt fabrication techniques toward commercial production of electro-optical PCBs



STEVENAGE
CIRCUITS 
TAKING TECHNOLOGY FURTHER

Deployment by end-users of OPCB technology into various applications

Data Storage / processing

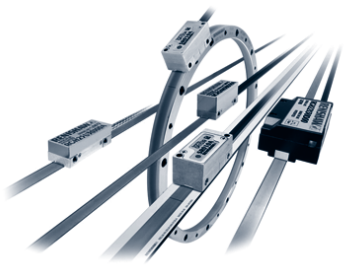
High density, fast communication within storage backplanes

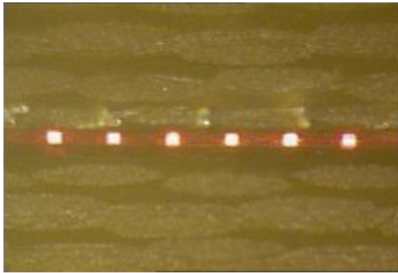
Sensors

Flexible optical sensors for biomedical applications

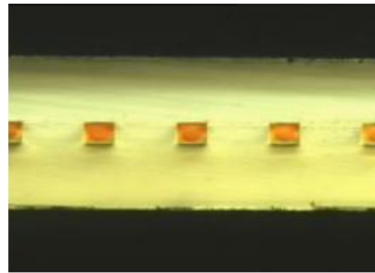
Military

Robust, low EMI, high speed communication within military vehicles

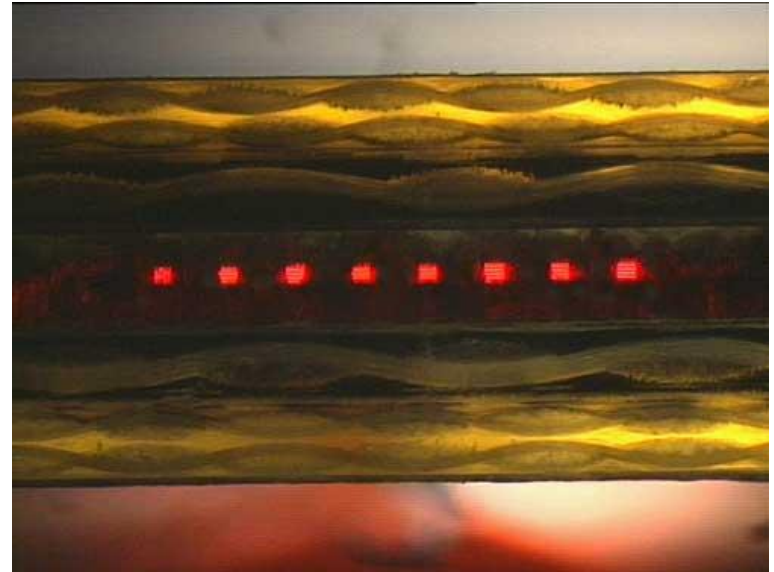




Source: Exxelis Ltd



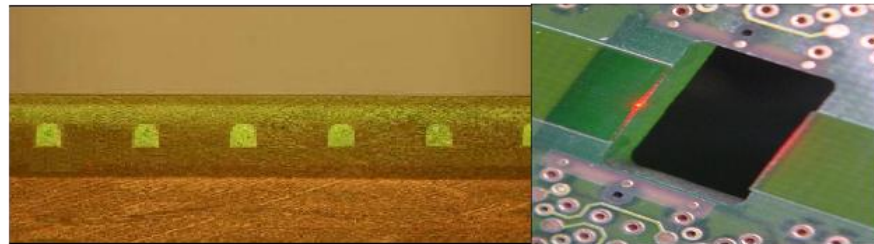
Source: Fraunhofer IZM



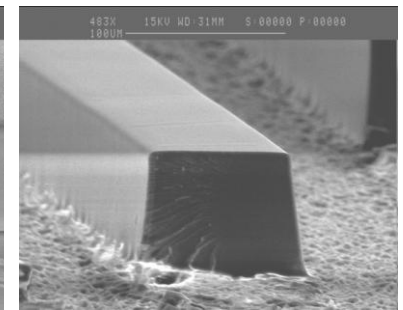
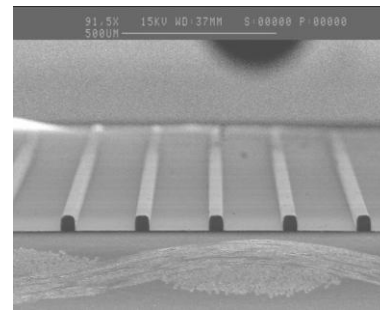
Source: Fraunhofer Institute



Source: Varioprint AG



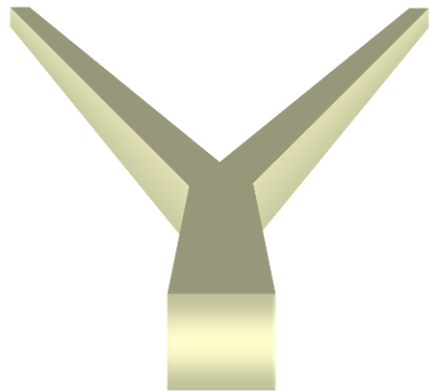
Source: IBM Zürich



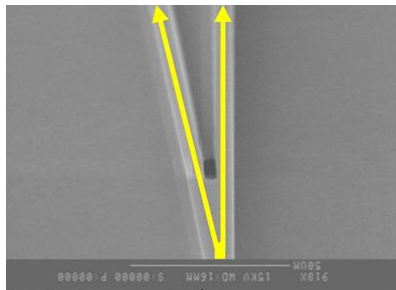
Source: Exxelis

Splitters

- ❑ 1 – many power splitters possible
- ❑ Depends on loss budget



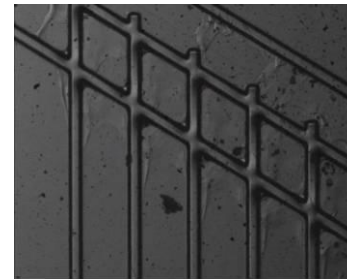
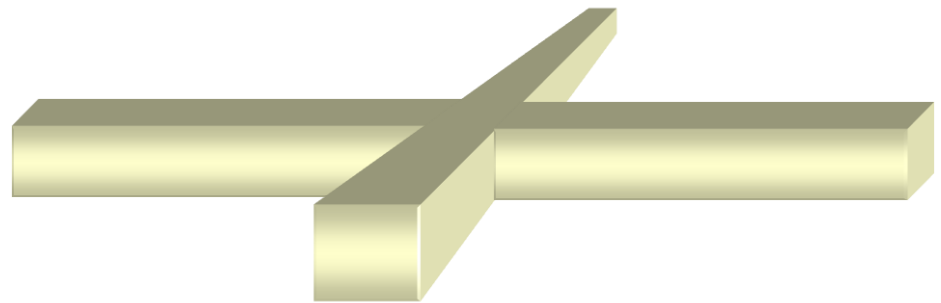
Source: IBM Zürich



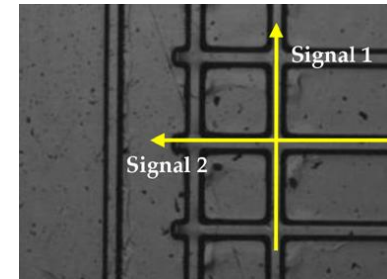
Source: Exxelis

Crossovers

- ❑ Signal crossovers on same layer without shorts

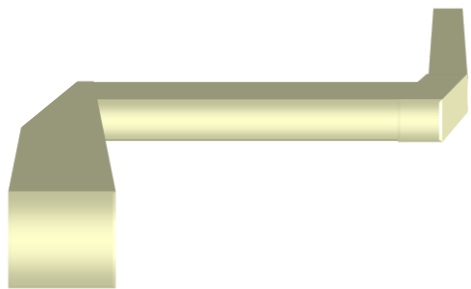


Source: Exxelis



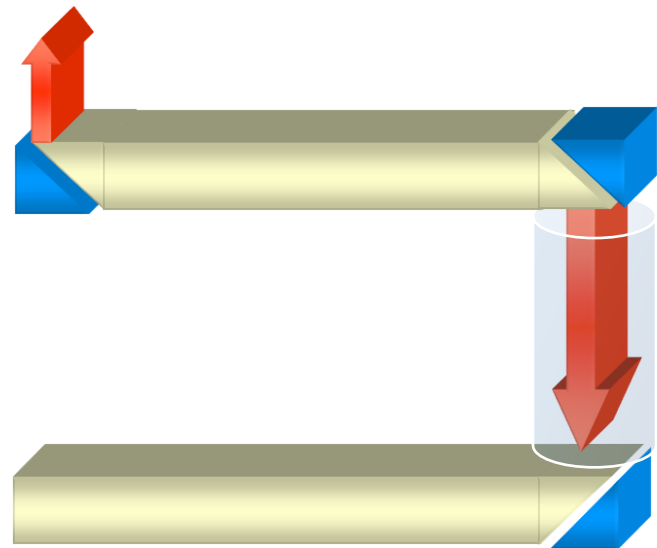
Right Angled Bends (In-plane)

- ❑ Overcomes bend radius restrictions
- ❑ Allows higher density routing

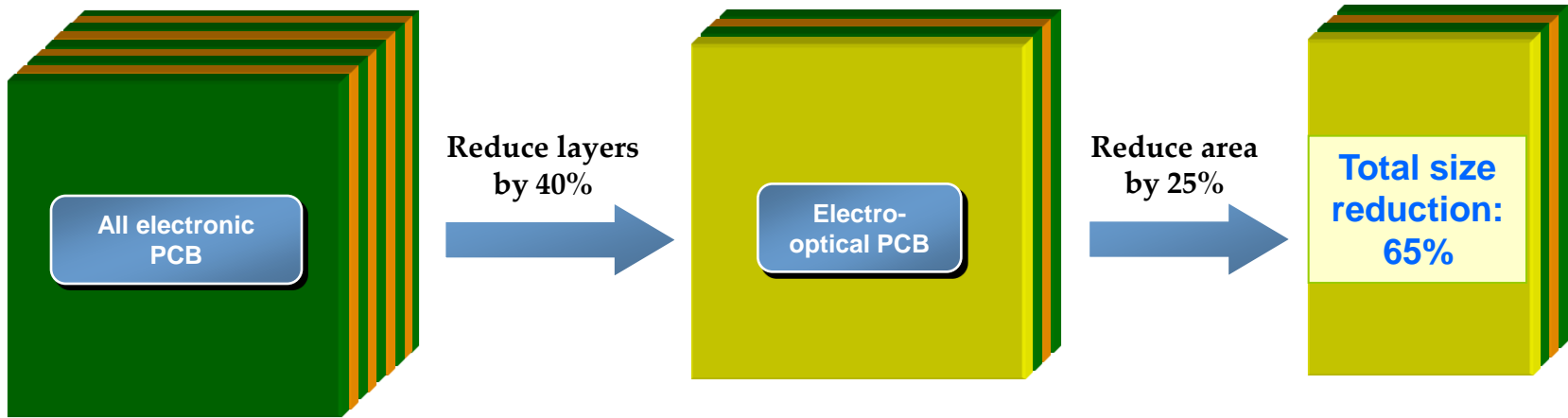


Right Angled Bends (Out-of-plane)

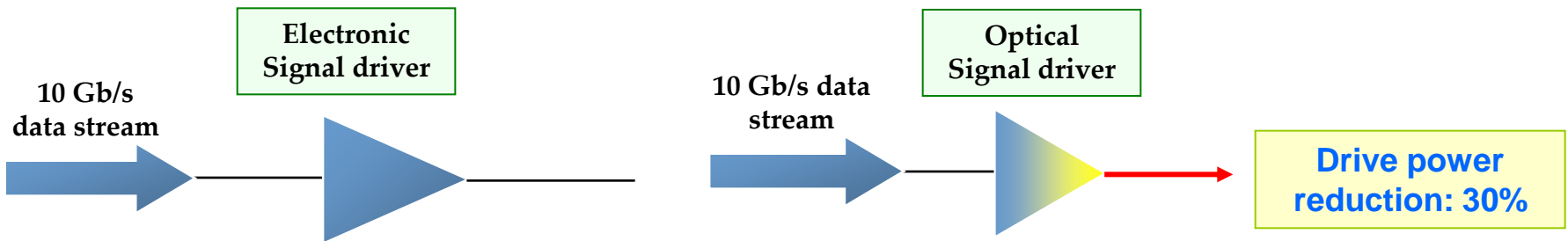
- ❑ Eases optical signal insertion
- ❑ Basis for optical vias



Reduction in PCB Waste Material

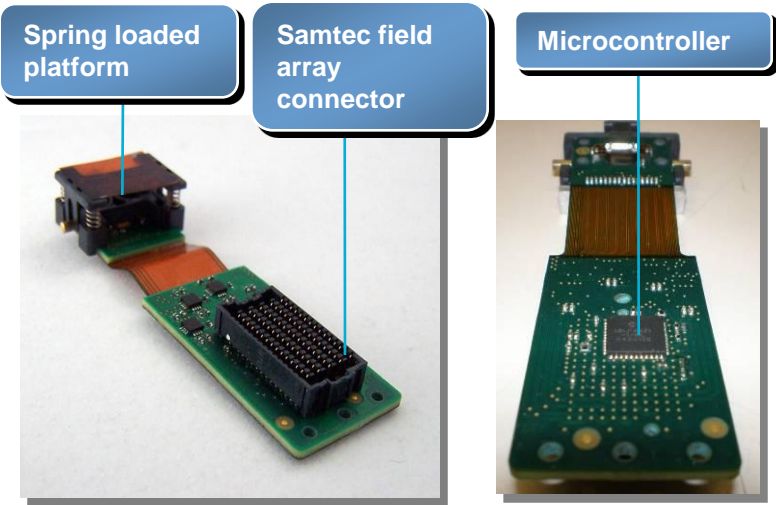


Reduced Power Consumption



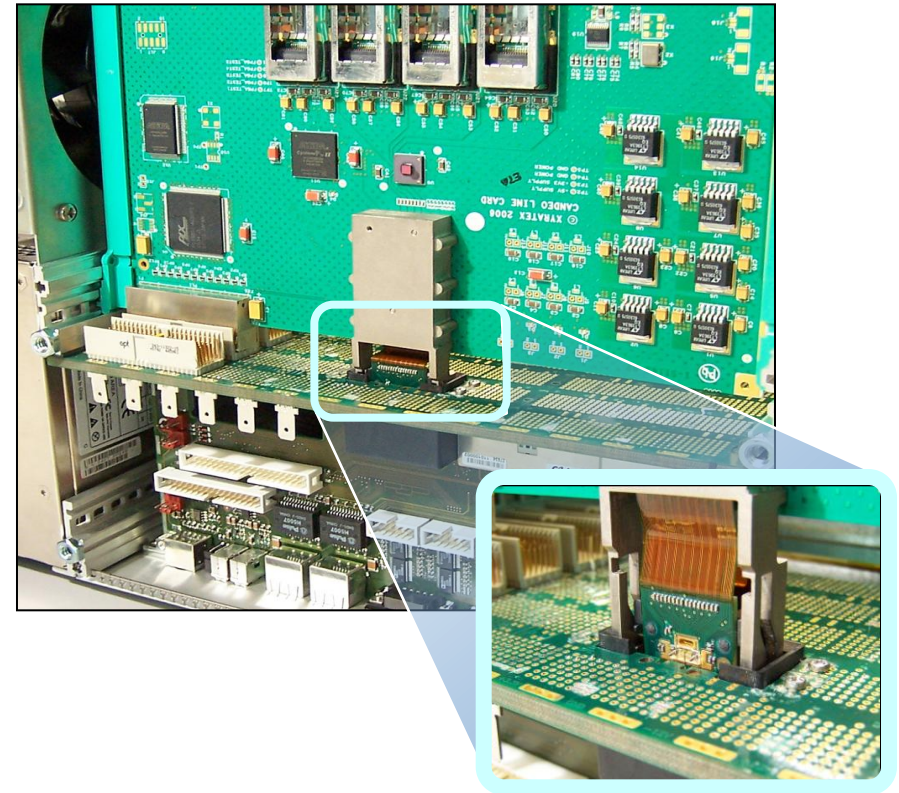
Parallel Optical Transceiver

- ❑ Small form factor
- ❑ 10 Gb/s per channel
- ❑ Microcontroller with I²C interface



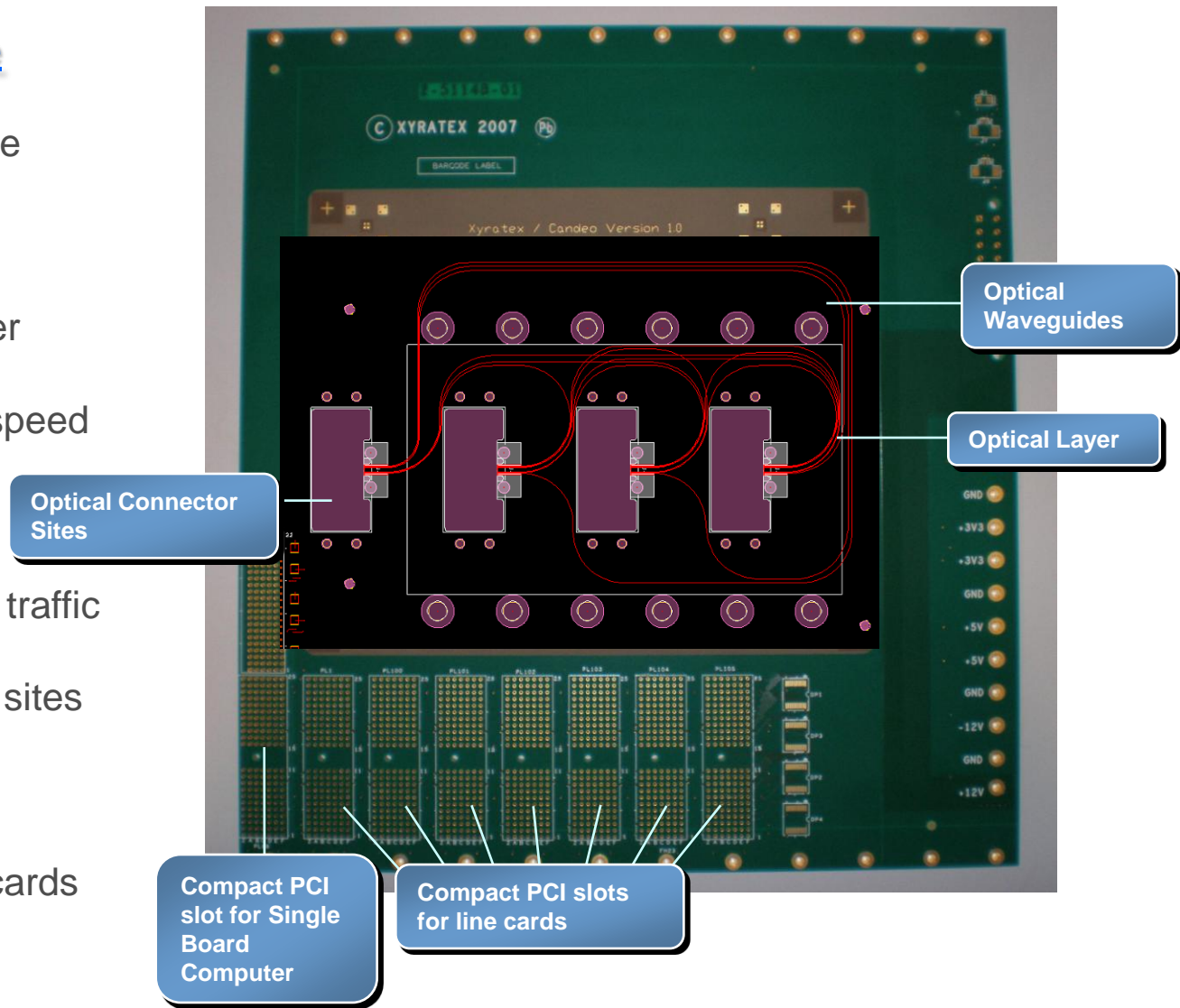
Backplane Connector Module

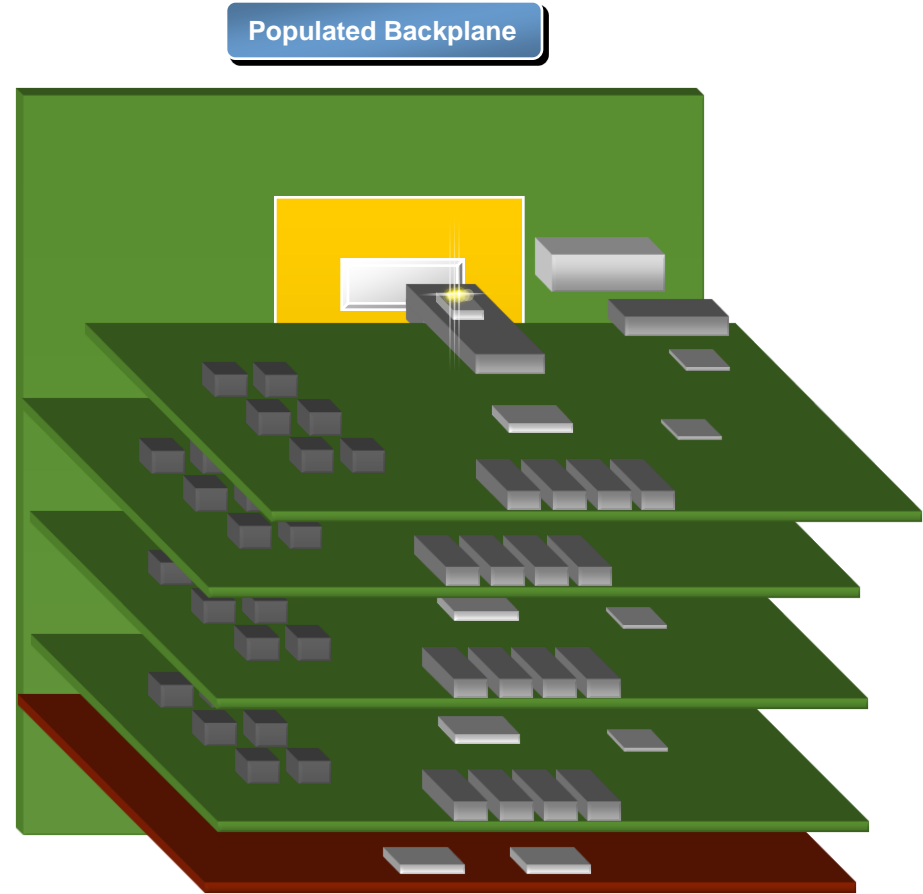
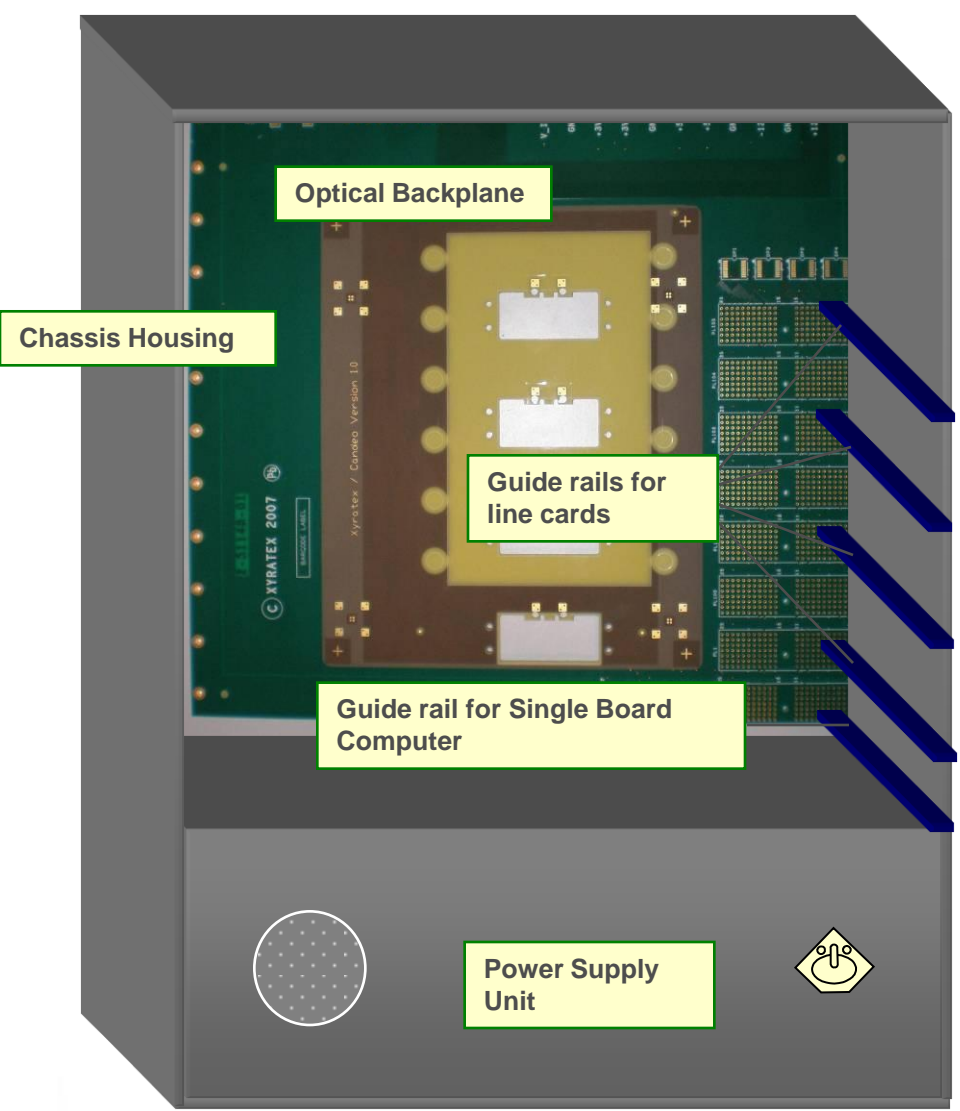
- ❑ Automated connector mechanism
- ❑ High precision alignment

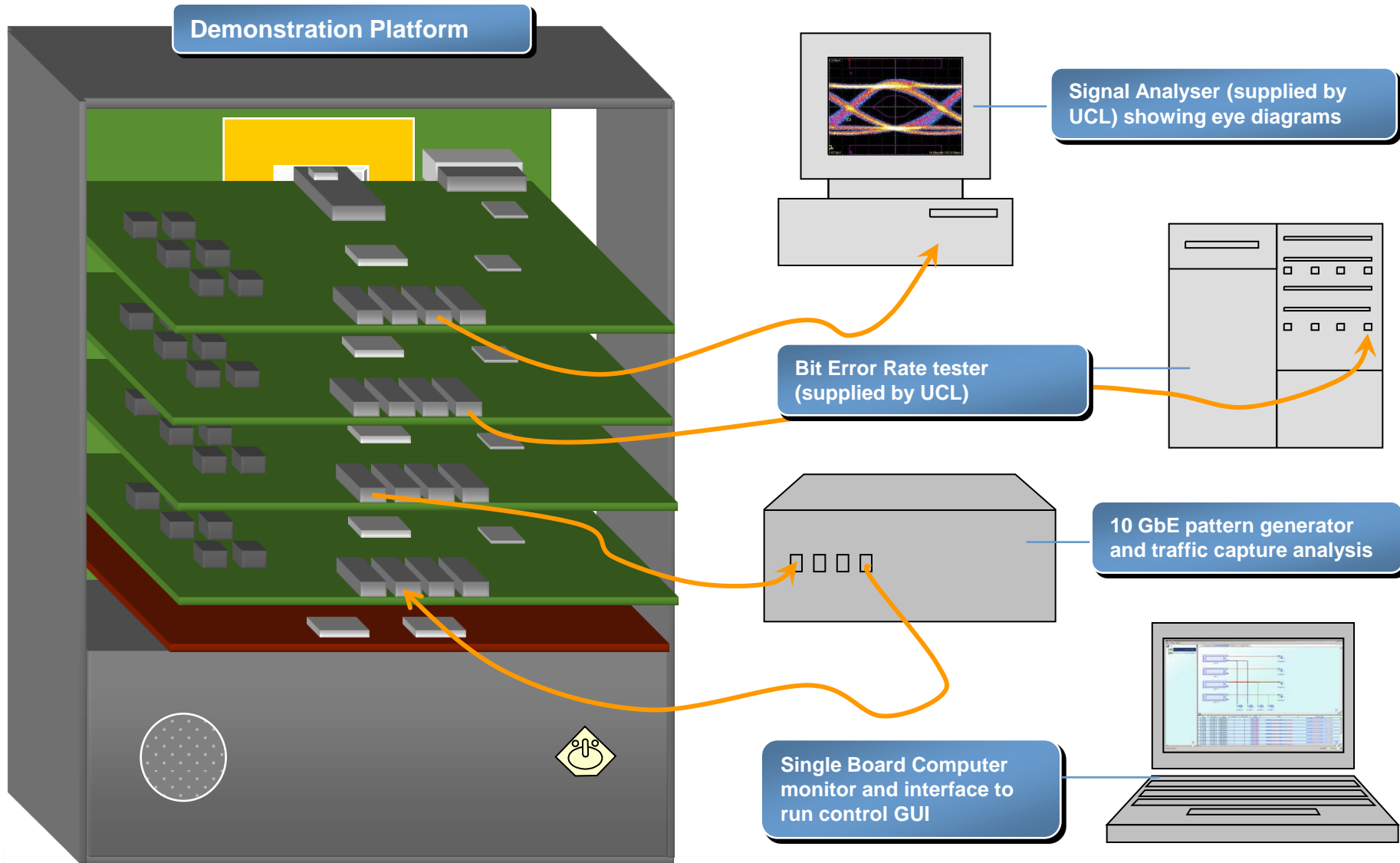


Electro-Optical Backplane

- ❑ Compact PCI architecture
- ❑ Electrical layers for power
- ❑ Electrical layers for low speed
- ❑ Optical layer for 10 Gb/s traffic
- ❑ 4 optical PCB connector sites
- ❑ Connector slots for line cards

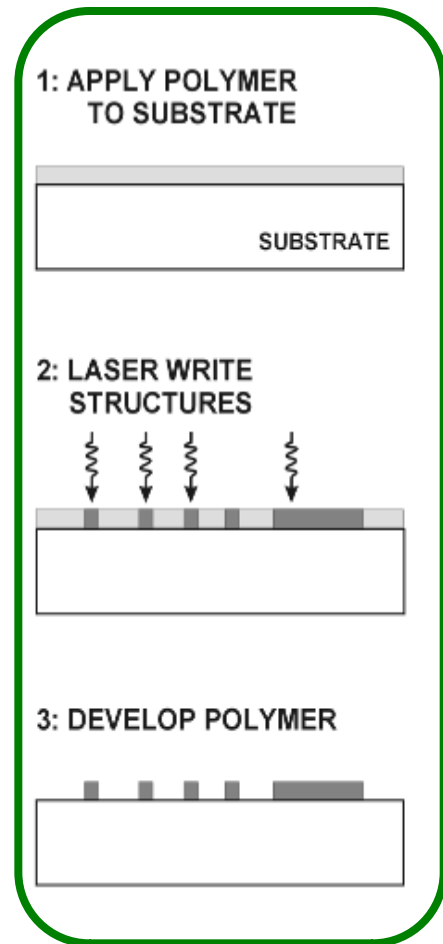
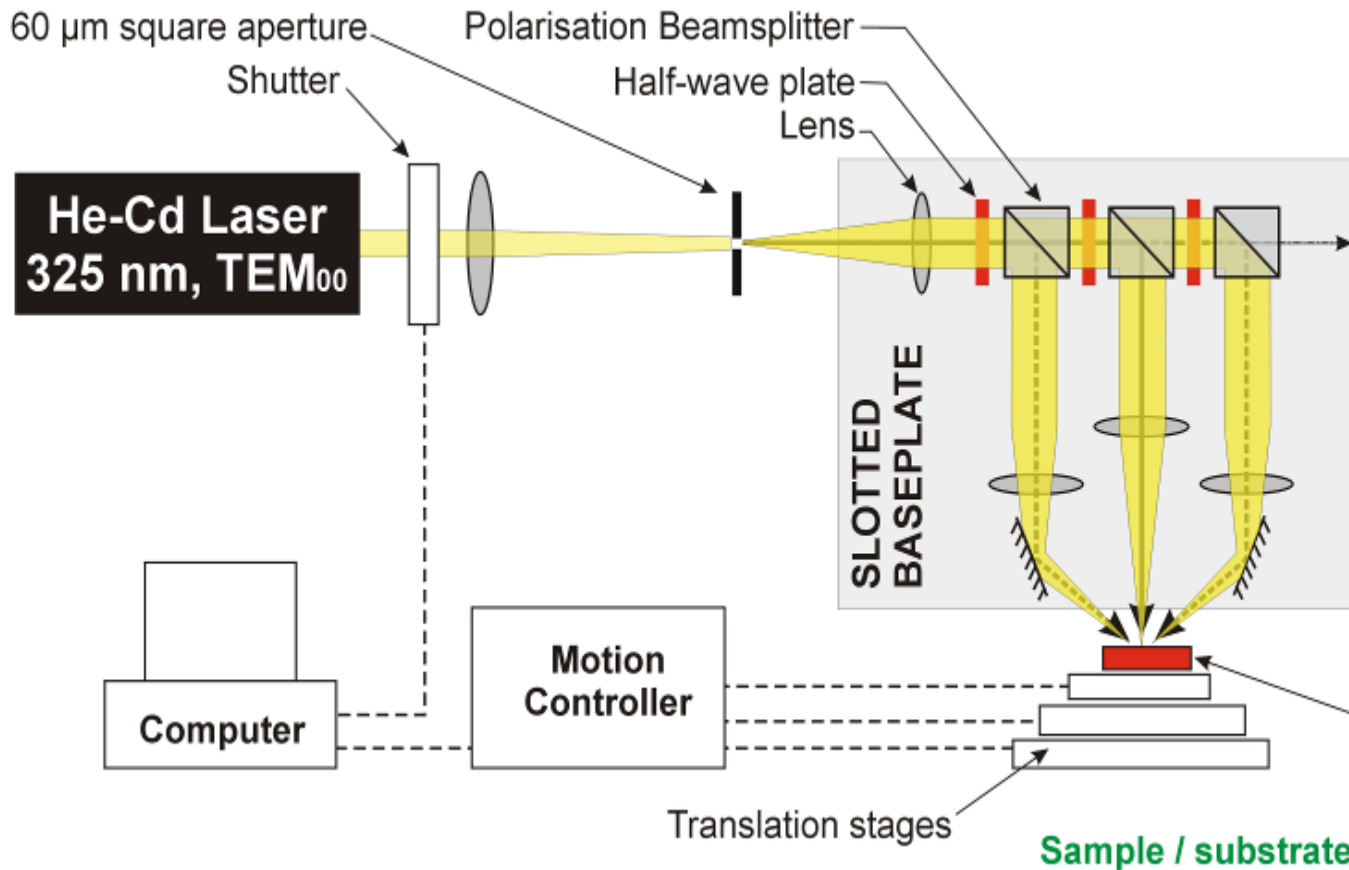






Andy Walker, Aongus McCarthy, Himanshu Suyal

- **Direct Laser-writing of waveguides**
 - Increase writing speeds and manufacturability
- **Photo-polymer Formulation**
 - Optimise for faster writing; alternative polymer systems; possible dry formulation
- **Writing over a large areas (400 – 500 mm long)**
 - Stationary “writing head” with board moved on long translation stage
- **Connectors**
 - Possible use of 45-deg out-of-plane mirrors
- **Advanced Optoelectronic Integration**

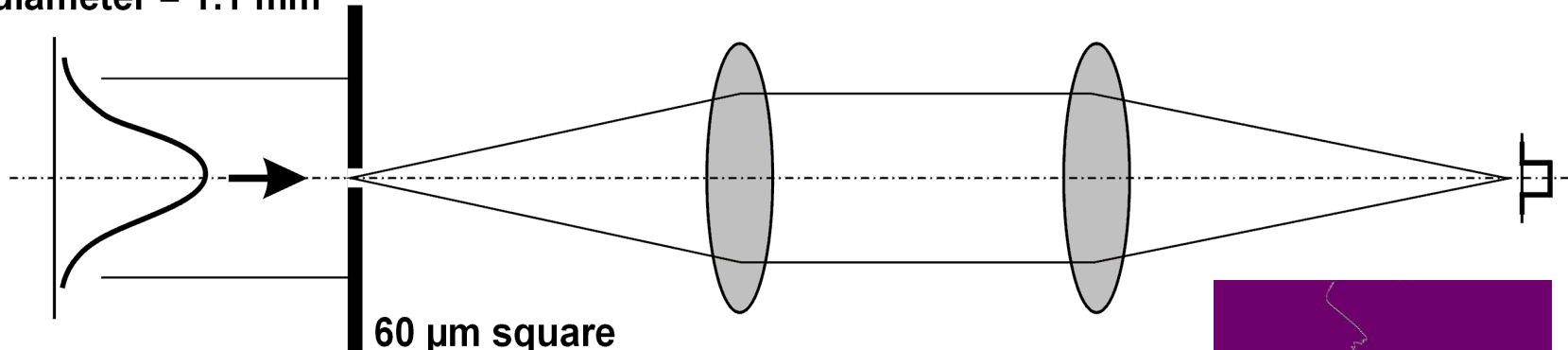


- **Slotted baseplate** mounted vertically over translation, rotation & vertical stages; components held in place with magnets
- By using two opposing 45° beams we minimise the amount of substrate rotation needed

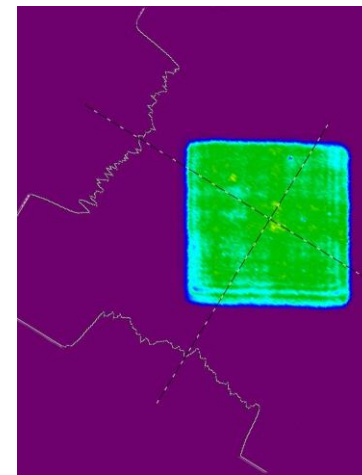
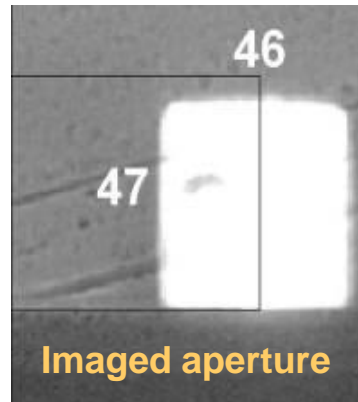
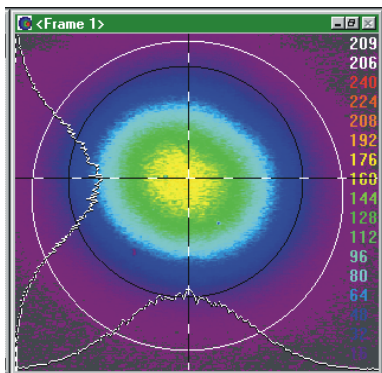
– flat-top, rectangular laser spot

Gaussian beam diameter = 1.1 mm

Imaging system / lenses



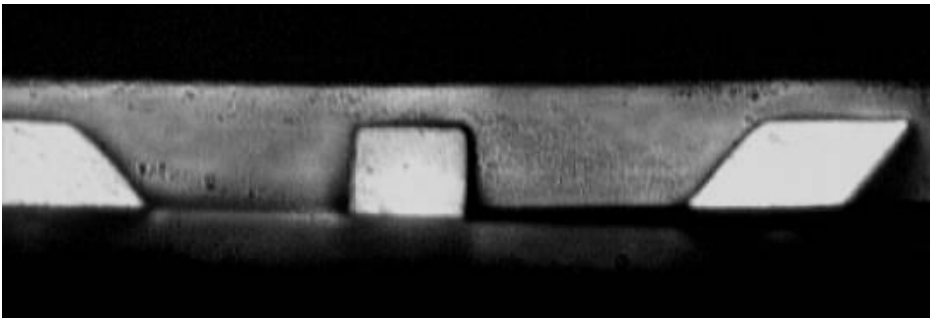
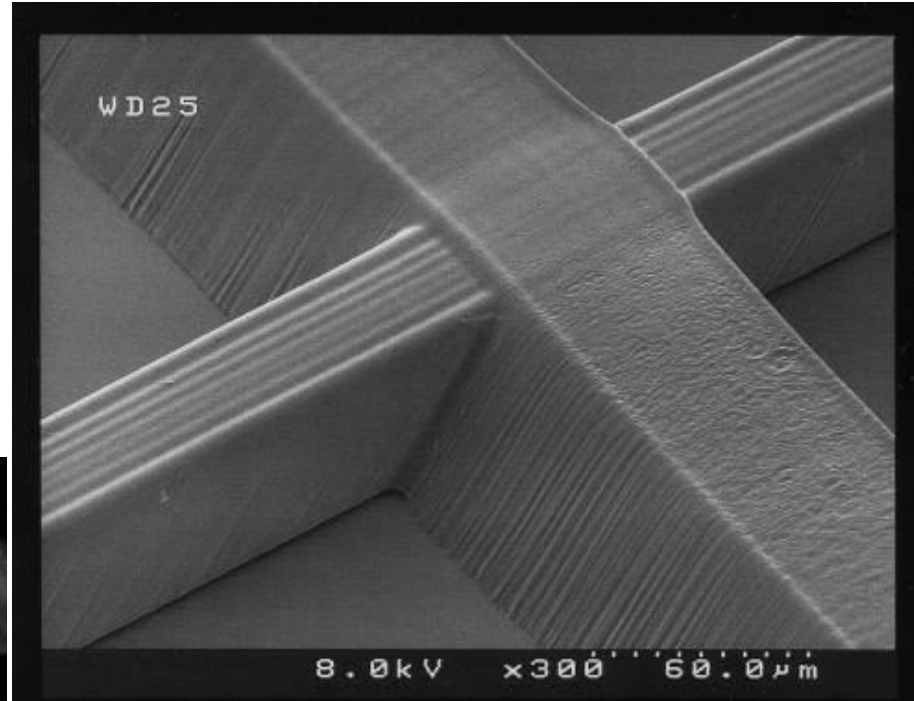
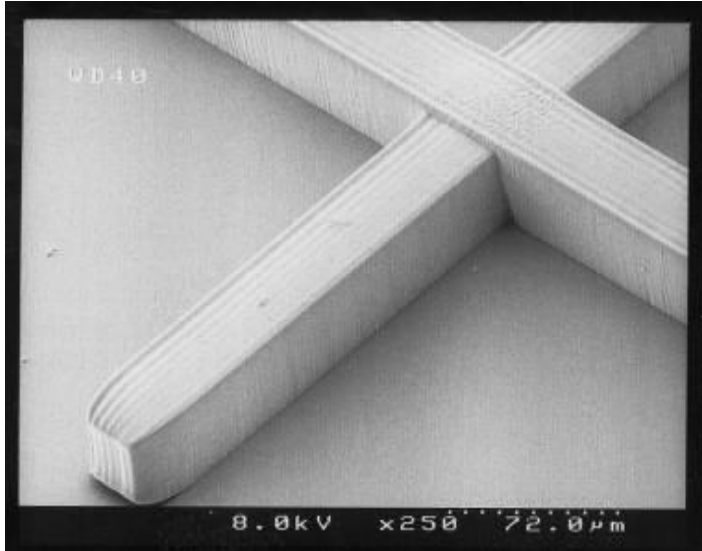
60 μm square aperture



Images of the resulting waveguide core cross-sections

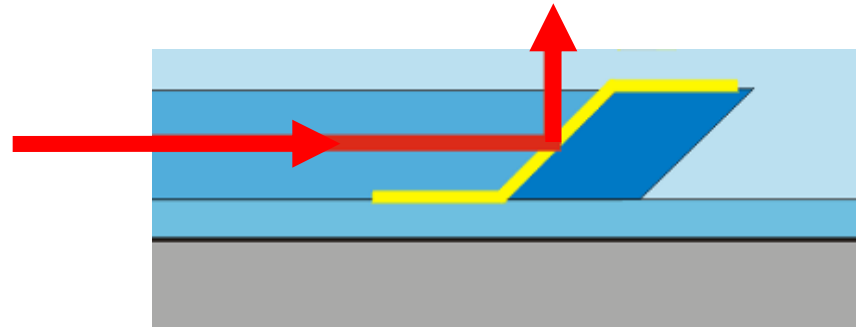
SEM images of polymer structures written using imaged 50 μm square aperture (chrome on glass)

- Writing speed: ~75 μm / s
- Optical power: ~100 μW
- Flat-top intensity profile
- Oil immersion
- Single pass



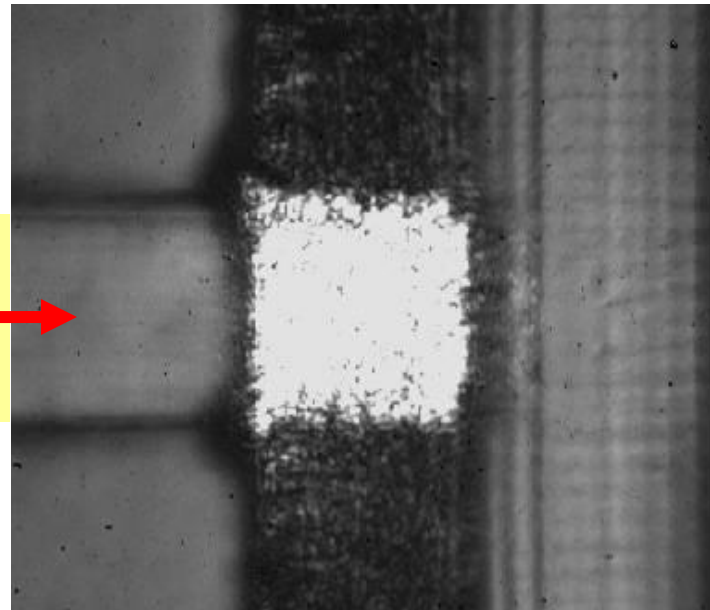
Optical microscope image showing end on view of the 45° surfaces

Out-of-plane coupling,
using 45-deg mirror (silver)



Microscope image looking
down on mirror
coupling light towards camera

OPTICAL INPUT



- Polymer Types: Acrylate (HWU custom & Exxelis) & polysiloxane systems (Dow Corning)
- Tuning of refractive index and viscosity is possible
- Equivalent to negative photoresist processing
- Compatible with a wide range of substrates
- Mechanical and thermal properties compatible with PCB processing
- “Wet” format processing; Possibility of a dry film format formulation
- Low optical loss at 850 nm (>0.1 dB/cm typical)
- Polymer deposition techniques include: Spinning, doctor-blading, casting, spray coating

- **Polymer system / formulation**
- **Writing speed**
 - New Aerotech stages capable of speeds of up to 2 m/s
- **Intensity profile**
 - Gaussian
 - Flat top (imaged aperture)
- **Optical power**
 - Gaussian beam: up to ~10 mW
 - Imaged aperture: up to ~1.5 mW
- **Oil immersion**
 - Permits writing of 45° surfaces
 - Excludes oxygen, which inhibits polymerisation process
- **Number of passes**
 - Exposure process is non-reciprocal
 - Can obtain better results with multiple fast passes than single slow pass

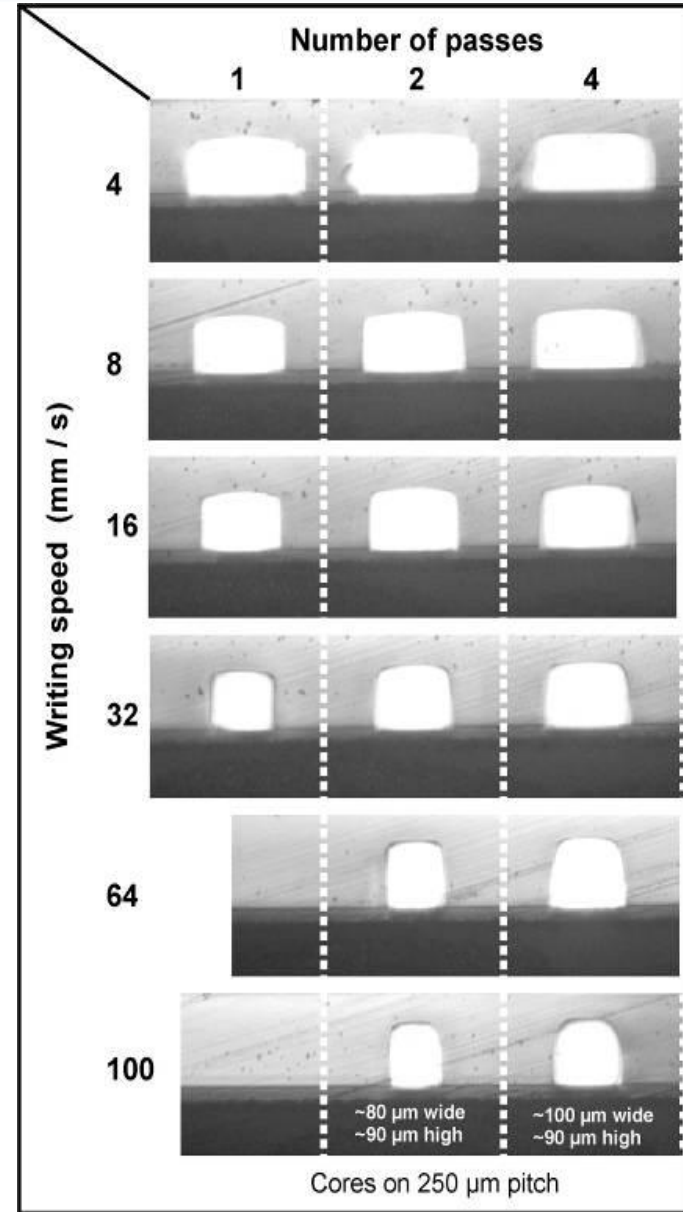
Laser-writing Parameters:

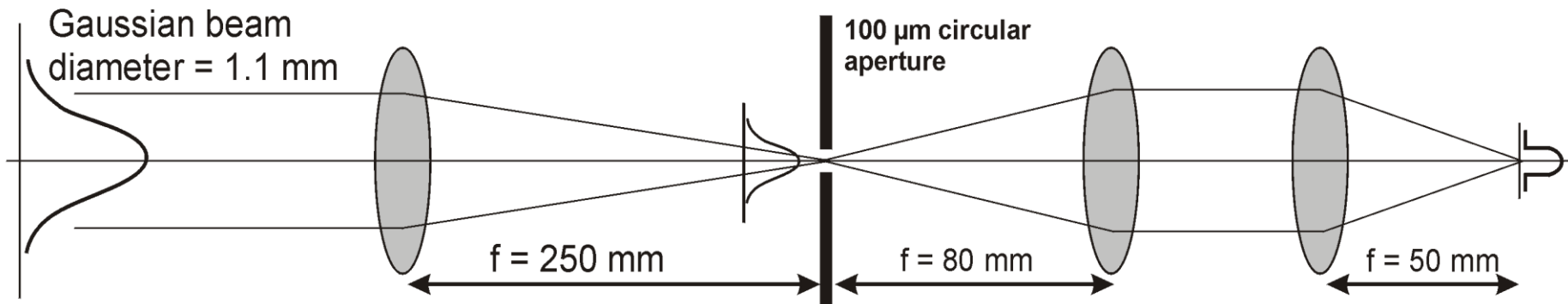
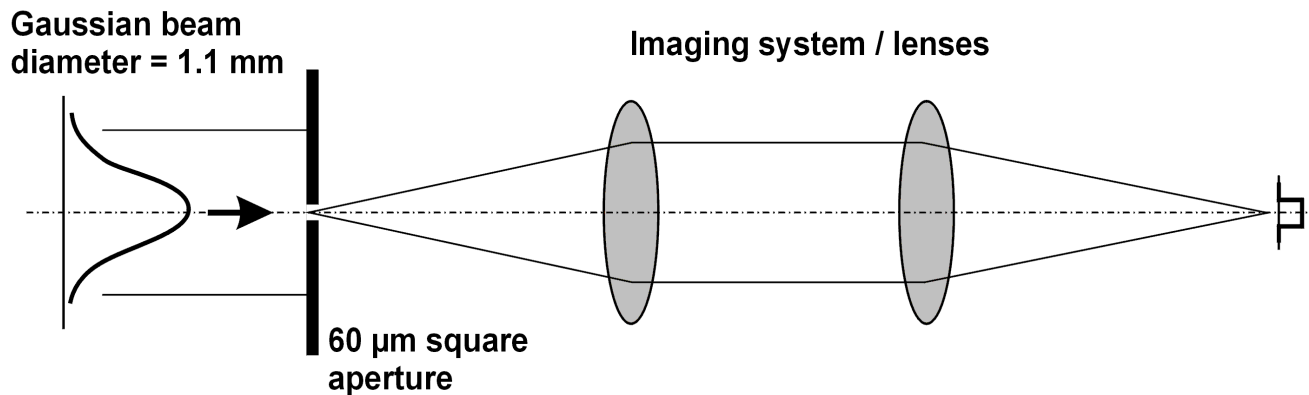
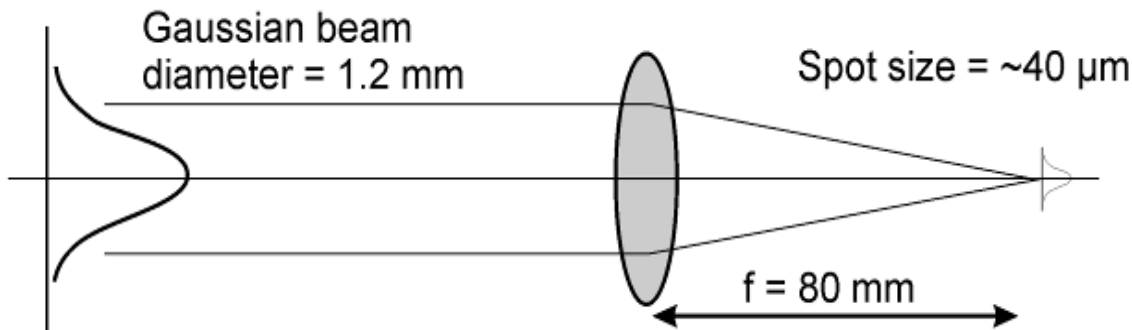
- Intensity profile: Gaussian
- Optical power: ~8 mW
- Cores written in oil

Polymer:

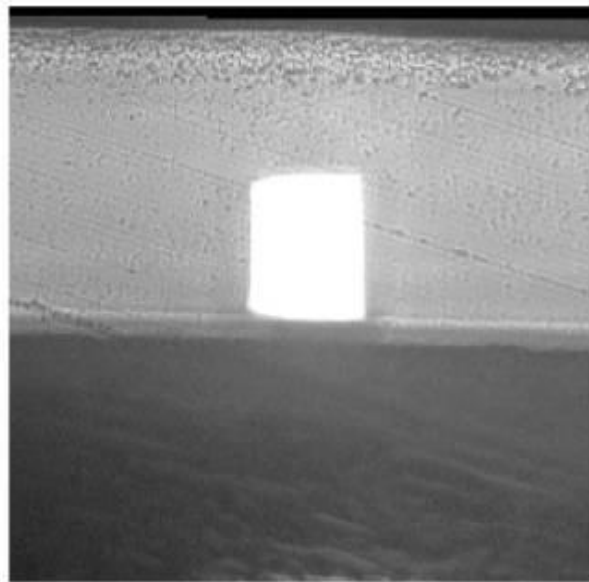
- Custom multifunctional acrylate photo-polymer
- Fastest “effective” writing speed to date: 50 mm/s

(Substrate: FR4 with polymer undercladding)

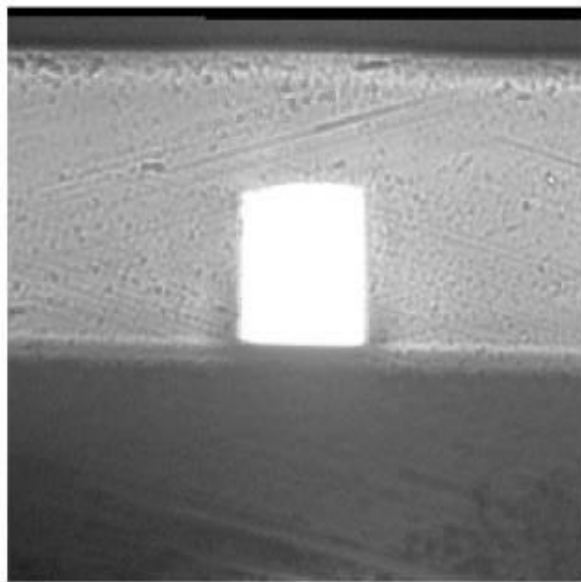




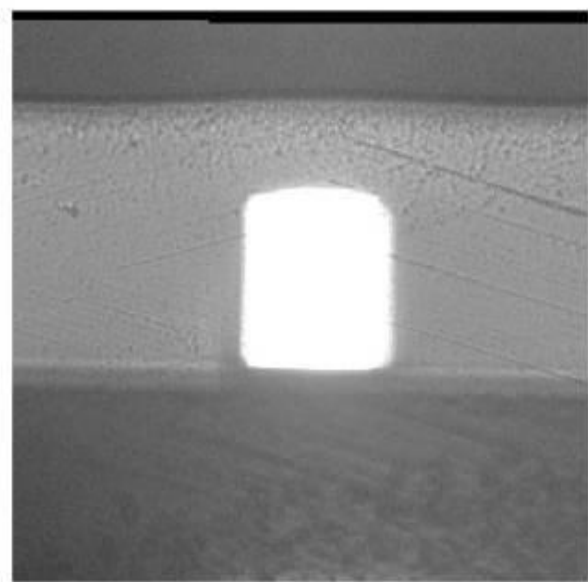
- 100 μm aperture was de-magnified
- Optical power at sample ~ 0.5 mW
- HWU custom photo-polymer



8 mm/s
63 x 74 μm

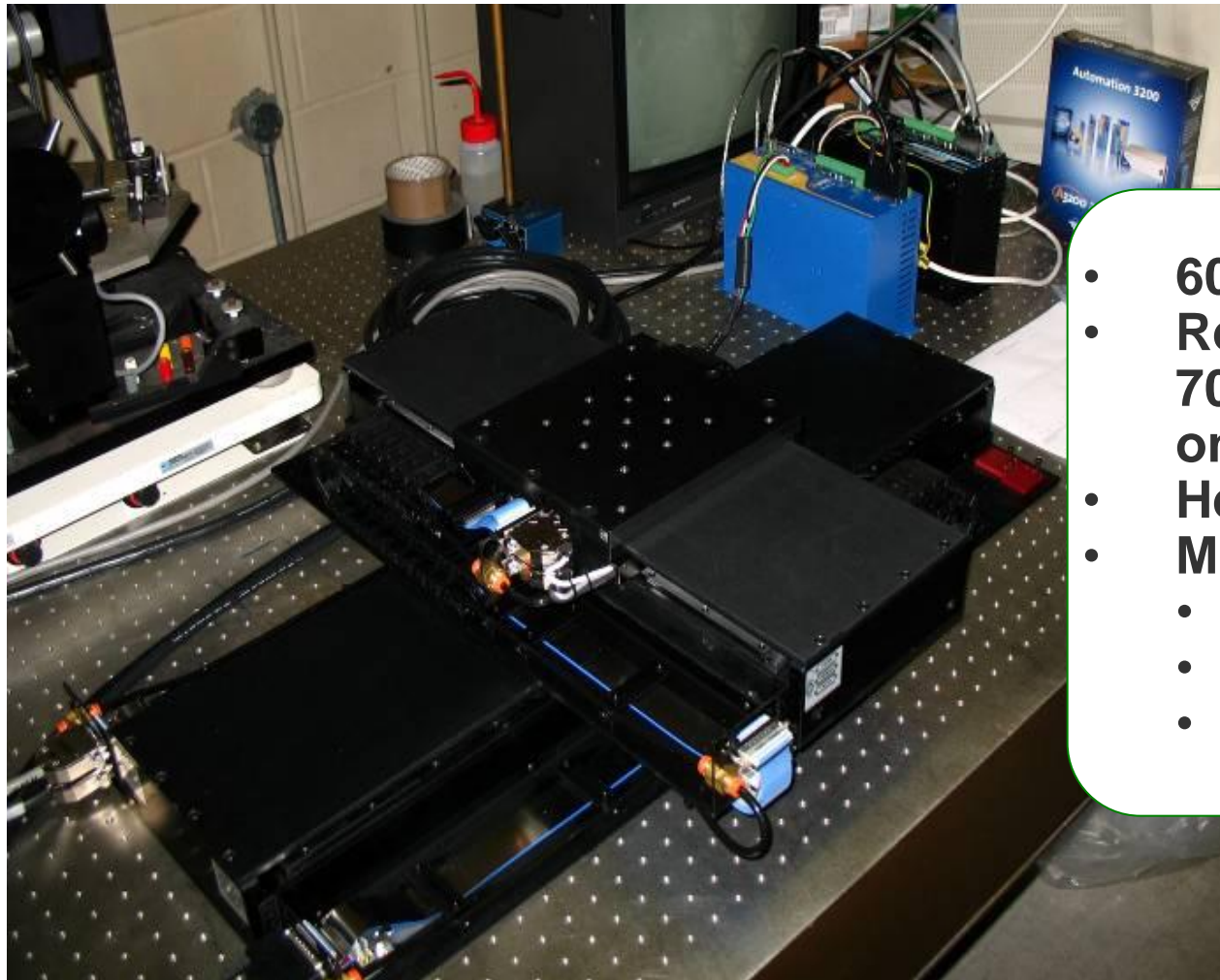


4 mm/s
69 x 78 μm

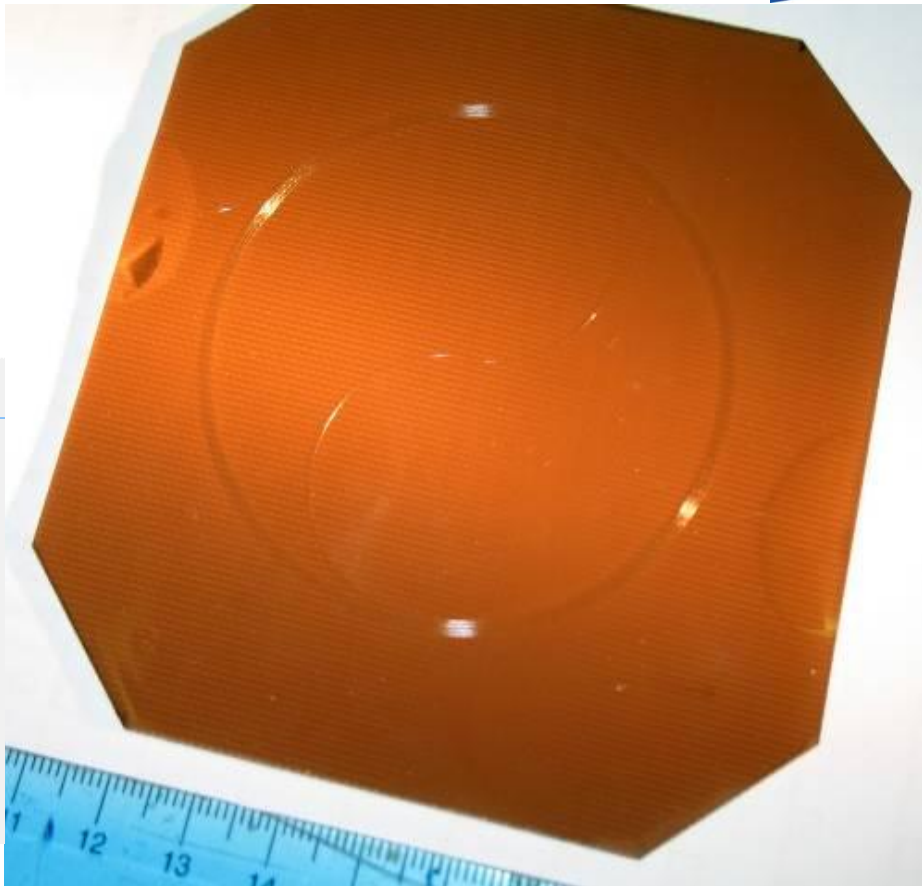
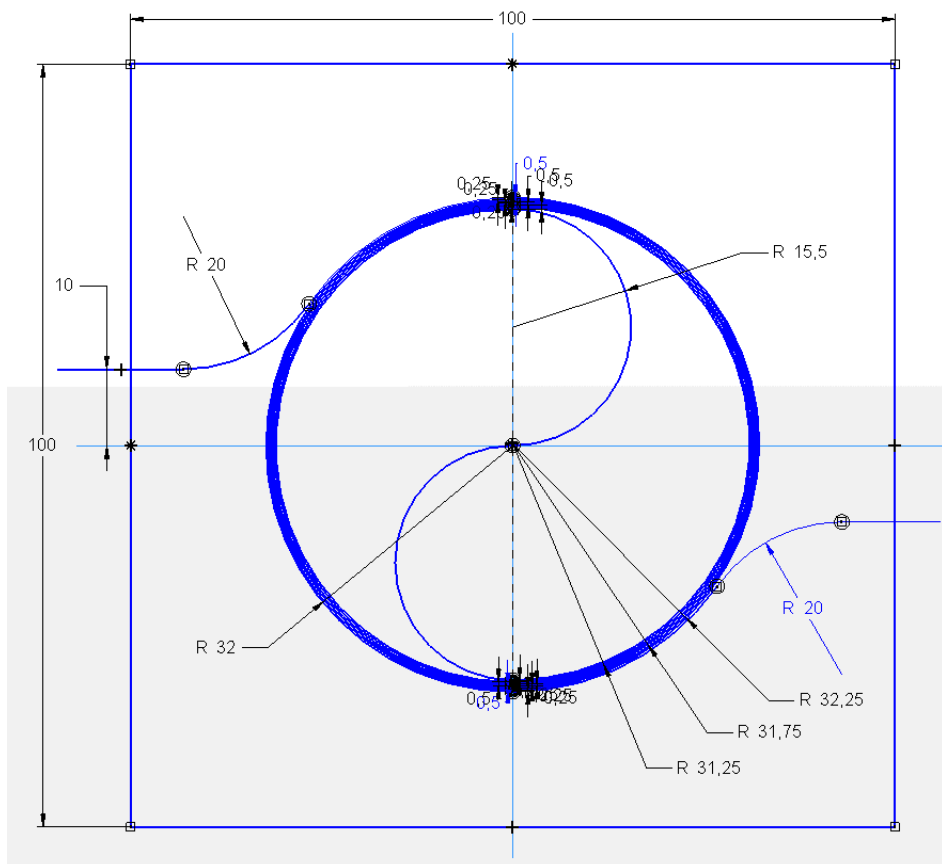


2 mm/s
76 x 84 μm

- Stationary “writing head” with board moved using Aerotech sub- μ m precision stages
- Waveguide trajectories produced using CAD program



- 600 x 300 mm travel
- Requires a minimum of 700 x 1000 mm space on optical bench
- Height: ~250 mm
- Mass:
 - 300 mm: 21 kg
 - 600 mm: 33 kg
 - Vacuum tabletop



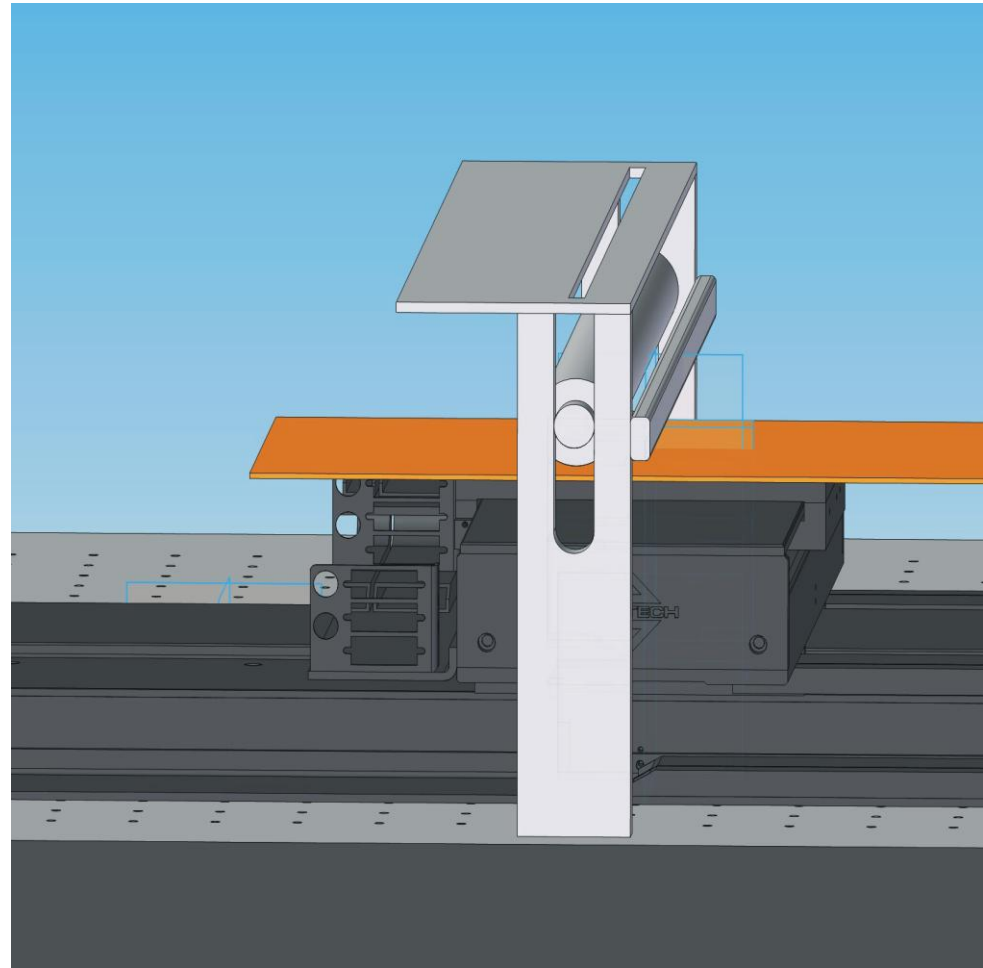
The spiral was fabricated using a Gaussian intensity profile at a writing speed of 2.5 mm/s on a 10 x 10 cm lower clad FR4 substrate. Total length of spiral waveguide is **~1.4 m**. The spiral was upper cladded at both ends for cutting.

Key challenge: Dispensing / applying a uniform layer of liquid photo polymer over a large are FR4 boards.

We plan to experiment with a number of techniques including the use of a roller system (as shown in the CAD drawing on right)

- Shims along edge
- Mylar sheet

Board Developing: Appropriate container for developing large FR4 boards after UV exposure



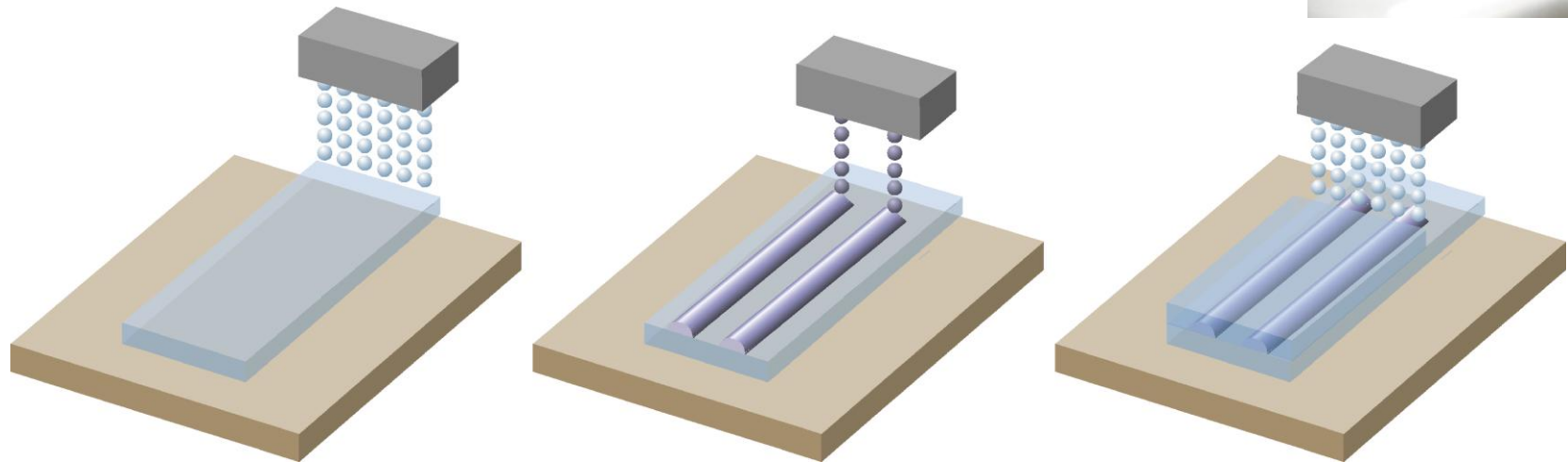
Inkjet Fabrication of Optical Waveguides

leMRC, 4th July 2008

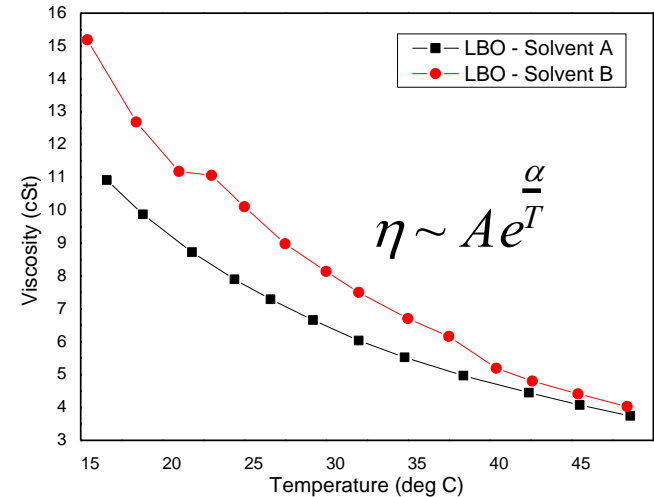
John Chappell, David Hutt

*Wolfson School of Mechanical and Manufacturing Engineering,
Loughborough University*

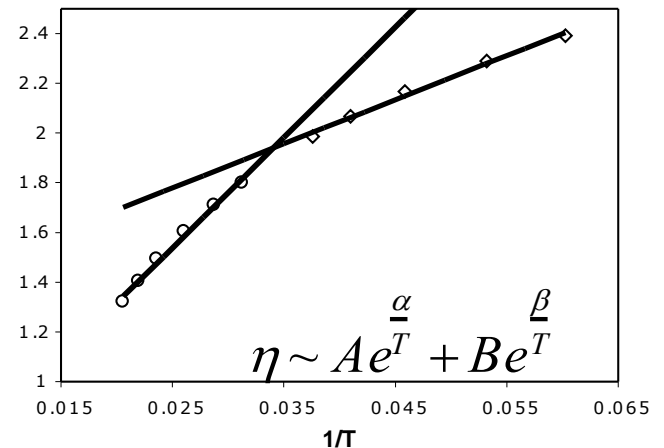
- Advantages
 - selective deposition of core and clad - less wastage: picolitre volumes
 - large area printing
 - low cost
- Target core dimensions of 50-100 microns height/width

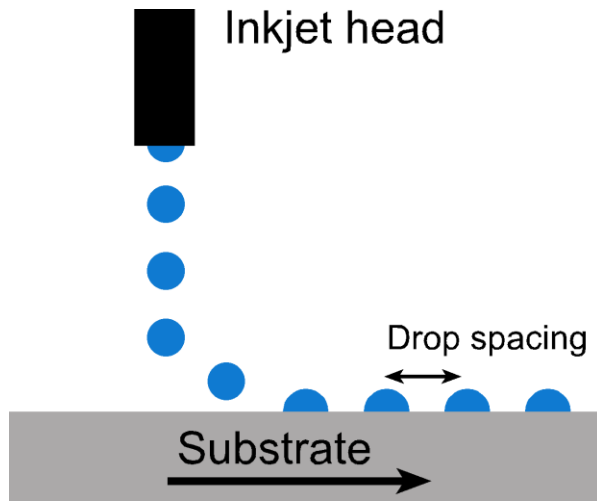


- Material properties tailored to inkjet head
- Optimising ‘waveform’ for each fluid - fluid dynamics
- Interaction of material with substrate: wetting, adhesion
- Control and stability of liquid structures
- Truemode (Exxelis) suitable material core/clad
- Solvent needed to tailor viscosity

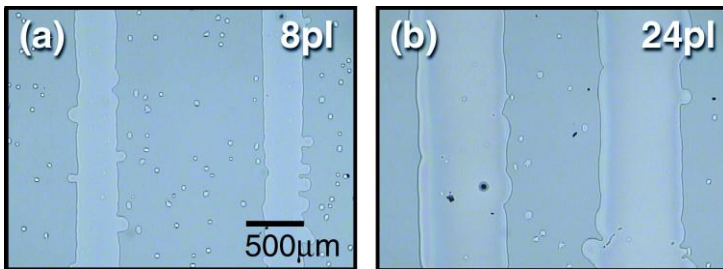


Core+ solvent A



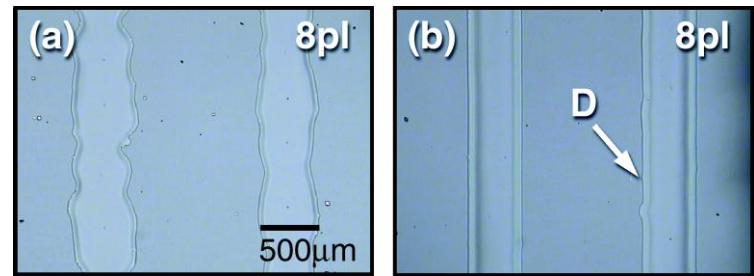


Room temperature substrate

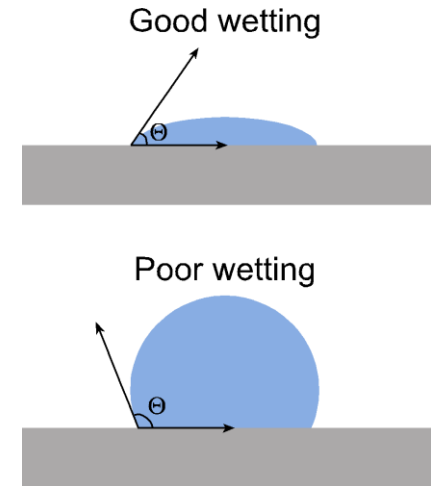
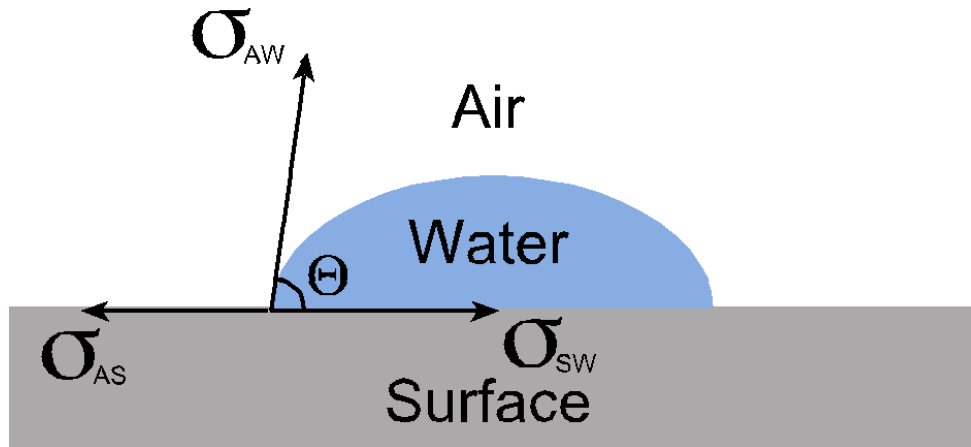


- Extensive spreading
- drop spacing of 70 microns

Substrate temperature $\sim -20^{\circ}\text{C}$

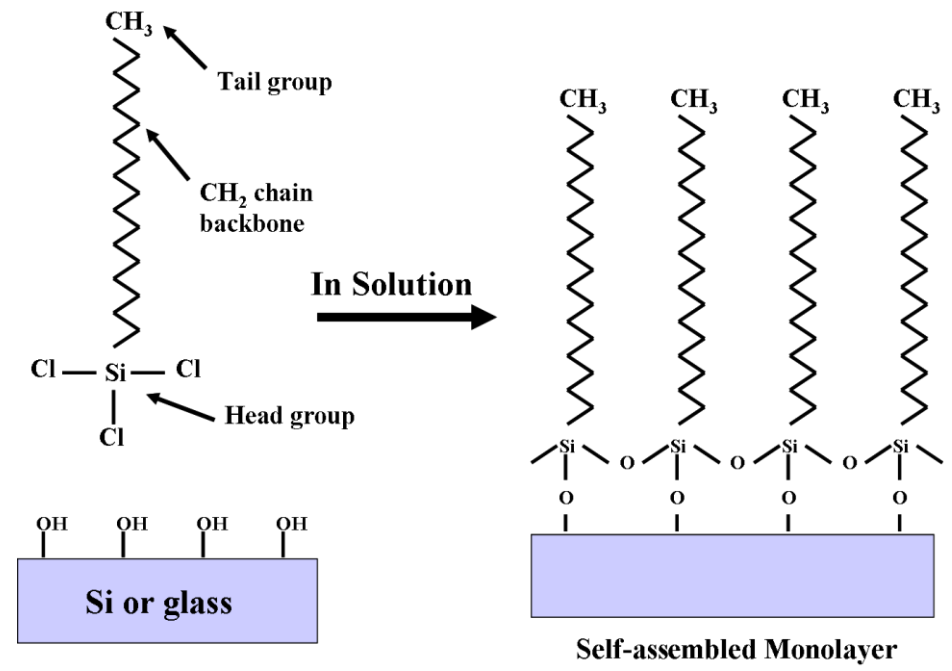


- Controlled spreading
- drop spacing of 17.5 microns (4x jetting frequency)
- (a) low BP solvent
(b) high BP solvent
- rate of solvent evaporation affecting line shape

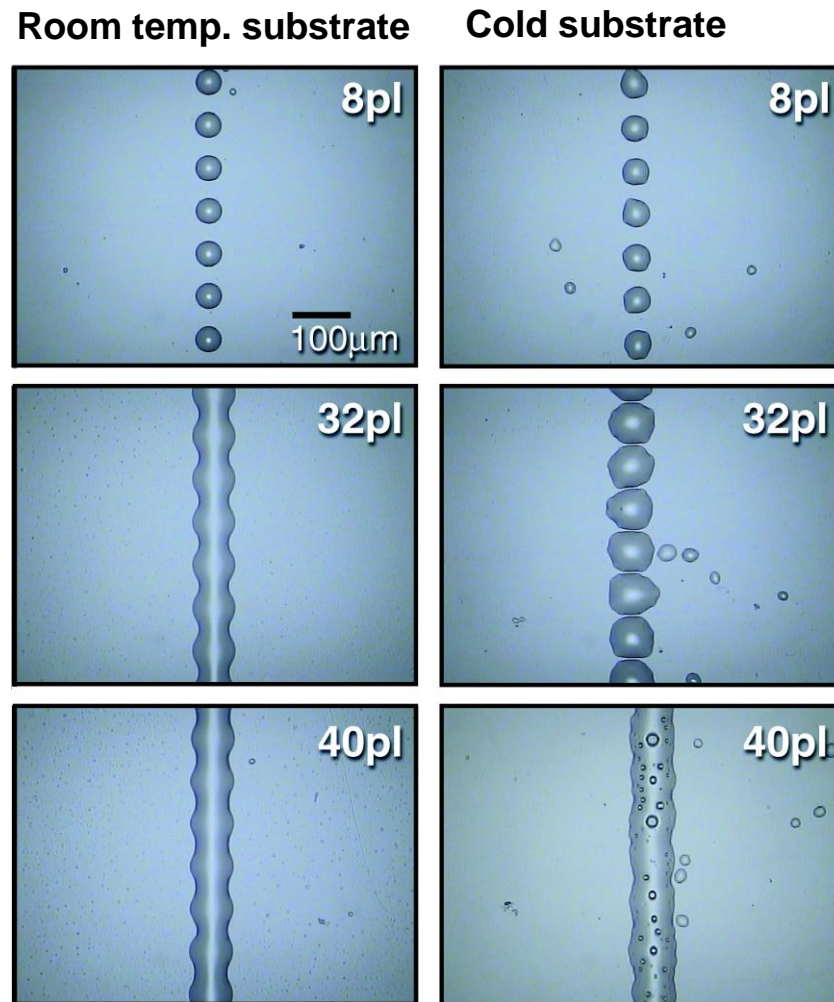


- Young's Equation
$$\sigma_{AS} = \sigma_{SW} + \sigma_{AW} \cos(\Theta)$$
- Balance of surface tensions acting at the contact lines
- Differences in material properties will affect the contact angle of the drop with the surface
- Surface tension (and viscosity) are temperature related - lowering the temperature increases surface tension (and viscosity)

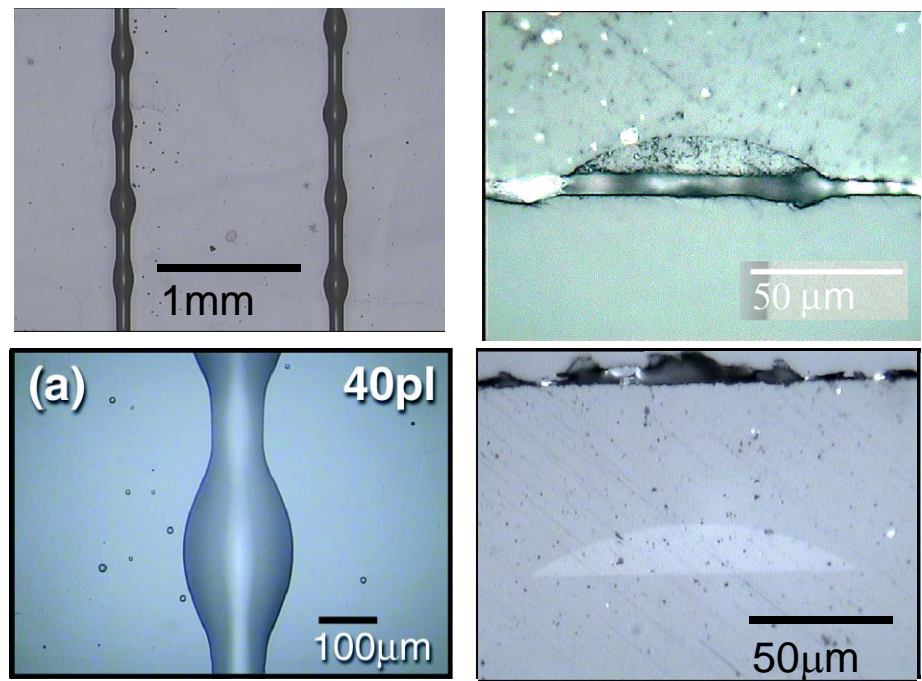
- Increase contact angle of liquid on substrate to reduce the wetting of liquid core
- Change the surface energy
- Choose a model hydrophobic surface - octadecyltrichlorosilane (OTS) on glass
- Cladding substrate shows water contact angles of $\sim 73^\circ$
- Gives water droplet contact angles $> 100^\circ$
- Creates adhesion problems



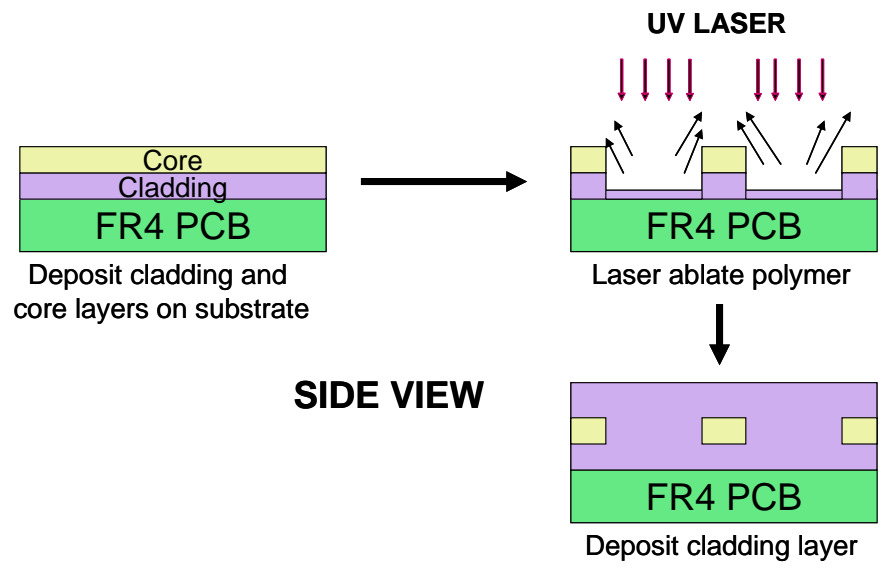
- Drop spacing of 70 microns
- Room temperature (left) and cold substrate (right)
- Discrete droplets – no splashing: material tailored well to inkjet system
- Temperature not the dominant factor in controlling feature shapes
- Possible demixing of solvent and core material at lower temperature



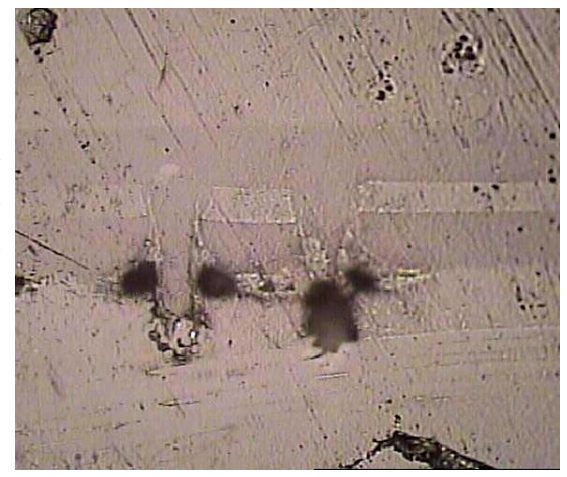
- Increasing the material deposited causes periodic features in the line shape - due to a combination of contact angles, viscosity and surface tension
- Surface roughness of 'tracks' is ~1nm - investigating optical properties of these structures
- Poor adhesion between treated glass and inkjetted material
- Aspect ratio of 5:1 - aiming towards 1:1



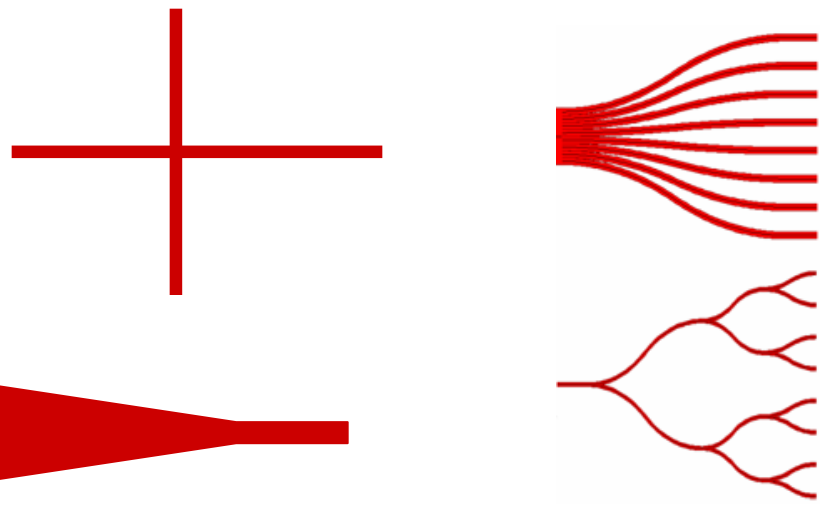
- Ablation to leave waveguides
- Excimer laser – Loughborough
- Nd:YAG – Stevenage Circuits
- Ablation process characterised
- Investigating machining of curved mirrors



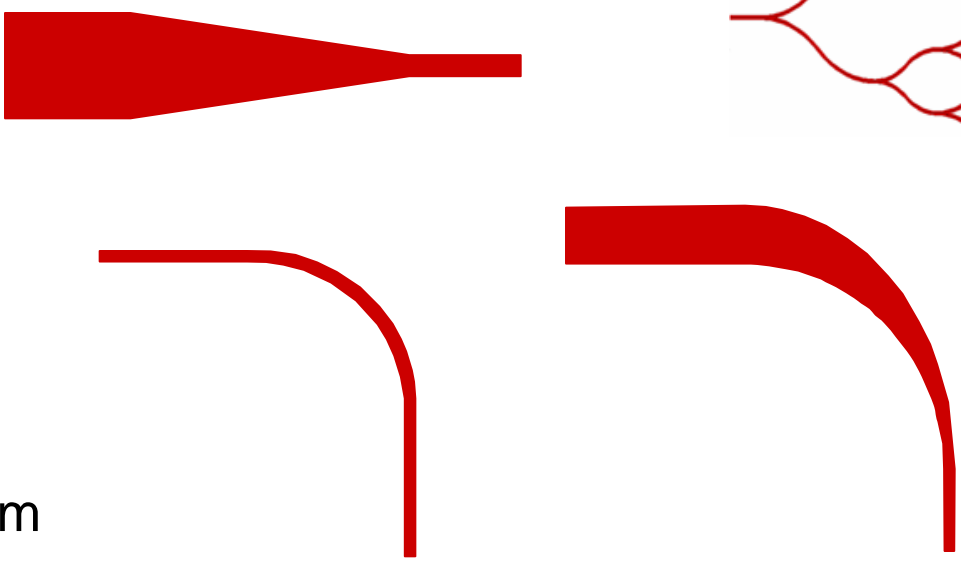
Upper cladding →
 Core →
 Lower cladding →

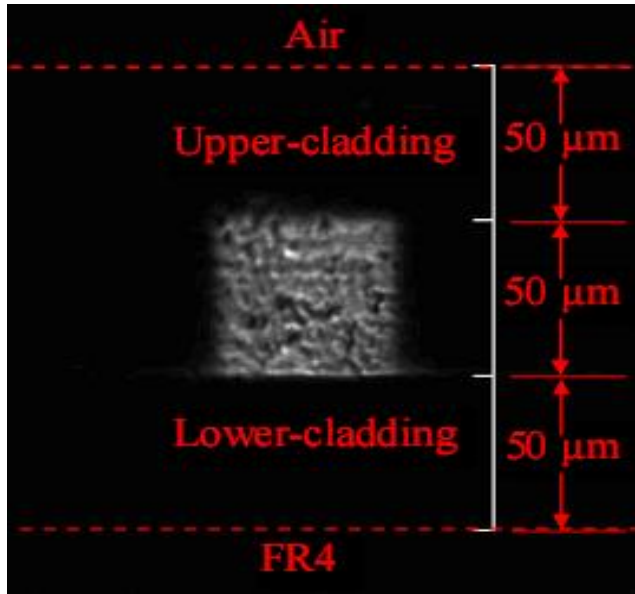


- ❑ Straight waveguides 480 mm x 70 μm x 70 μm
- ❑ Bends with a range of radii
- ❑ Crossings
- ❑ Splitters
- ❑ Spiral waveguides
- ❑ Tapered waveguides
- ❑ Bent tapered waveguides

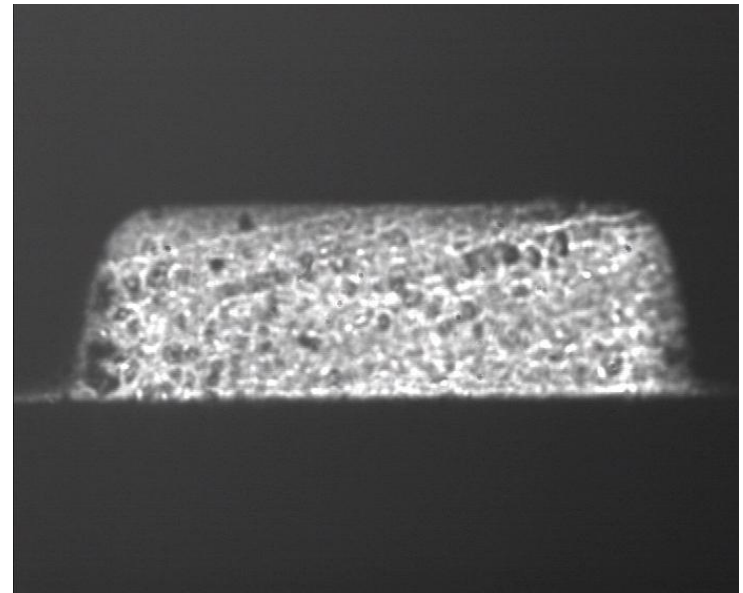


- ❑ Surface Roughness
- ❑ Loss
- ❑ Crosstalk
- ❑ Misalignment tolerance
- ❑ Bit Error Rate, Eye Diagram



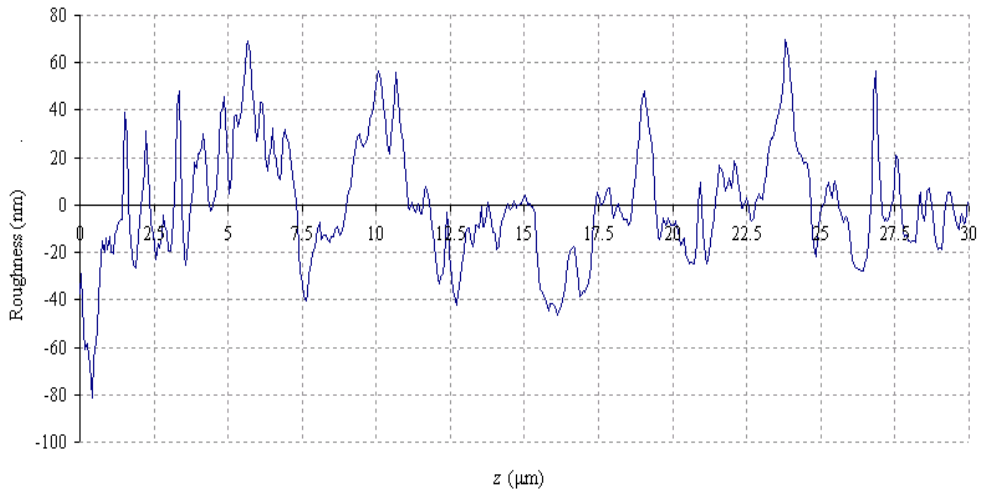


50 μm 50 μm waveguide



50 μm 140 μm waveguide

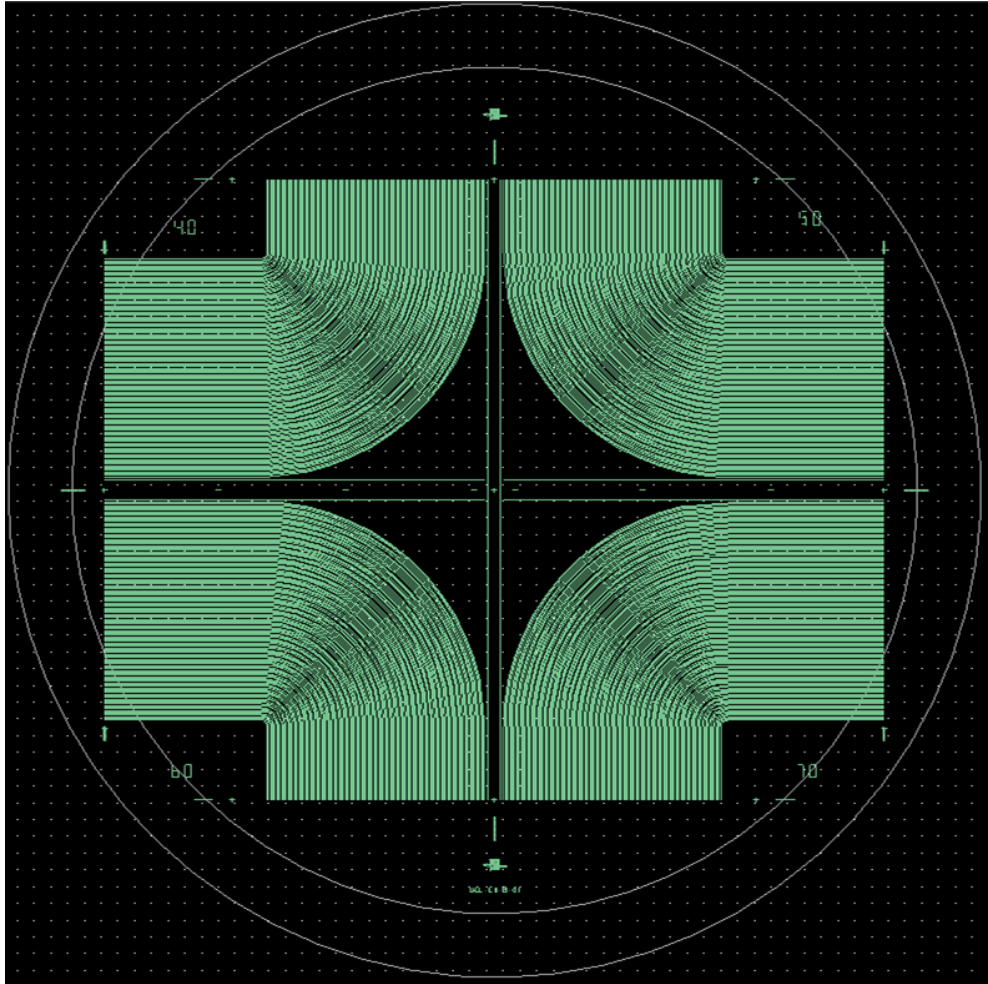
- Photolithographically fabricated by Exxelis
- Cut with a dicing saw, unpolished
- VCSEL illuminated

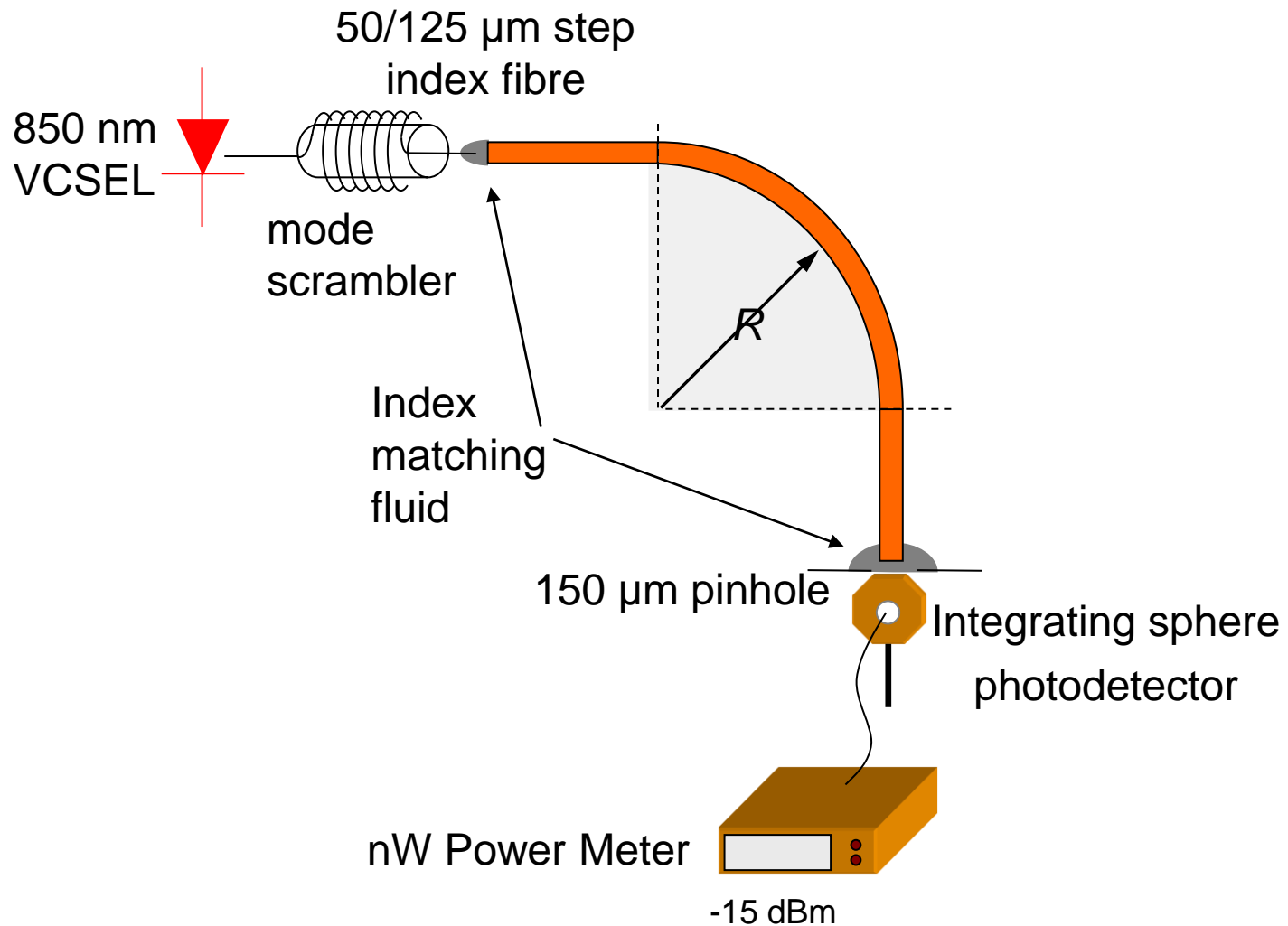


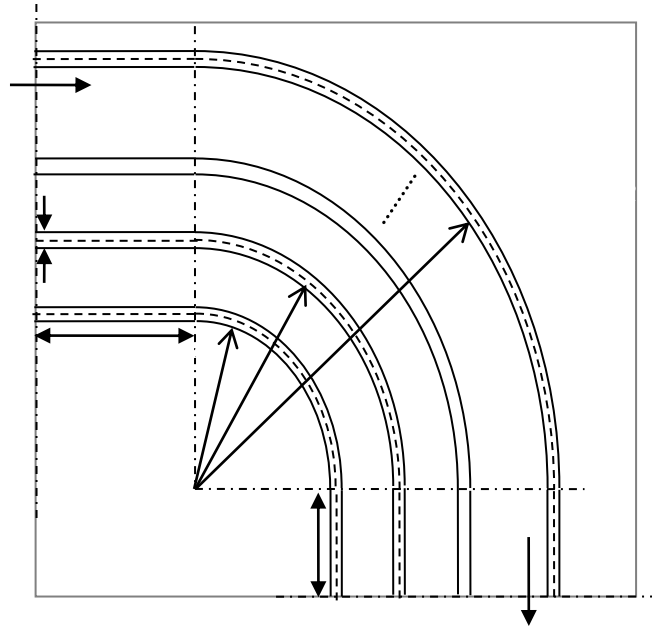
□ RMS side wall roughness: 9 nm to 74 nm



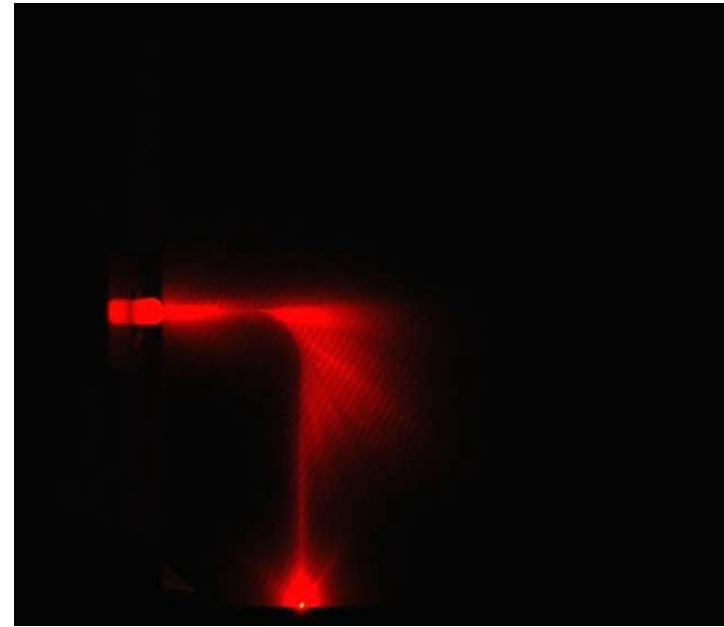
□ RMS polished end surface roughness: 26 nm to 192 nm.





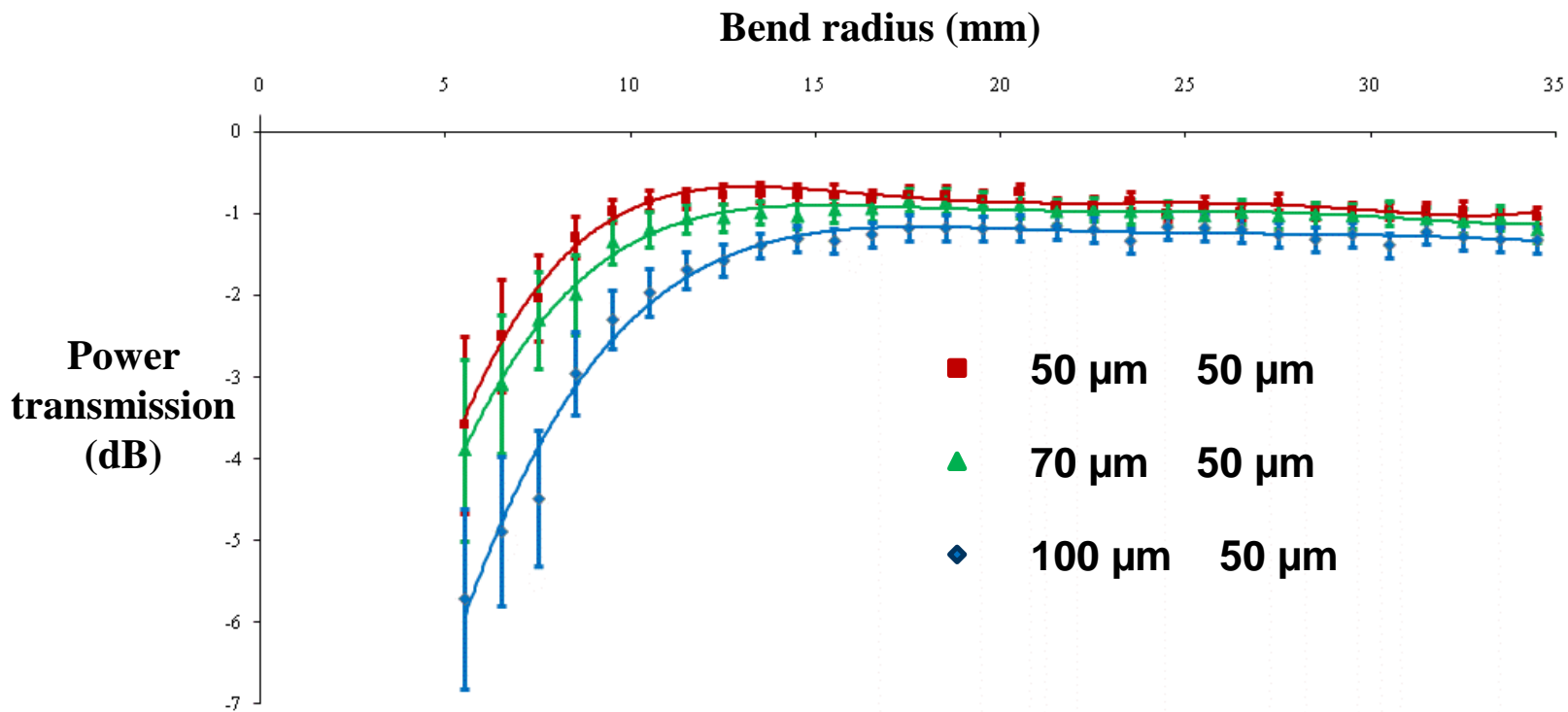


Schematic diagram of one set of curved waveguides.

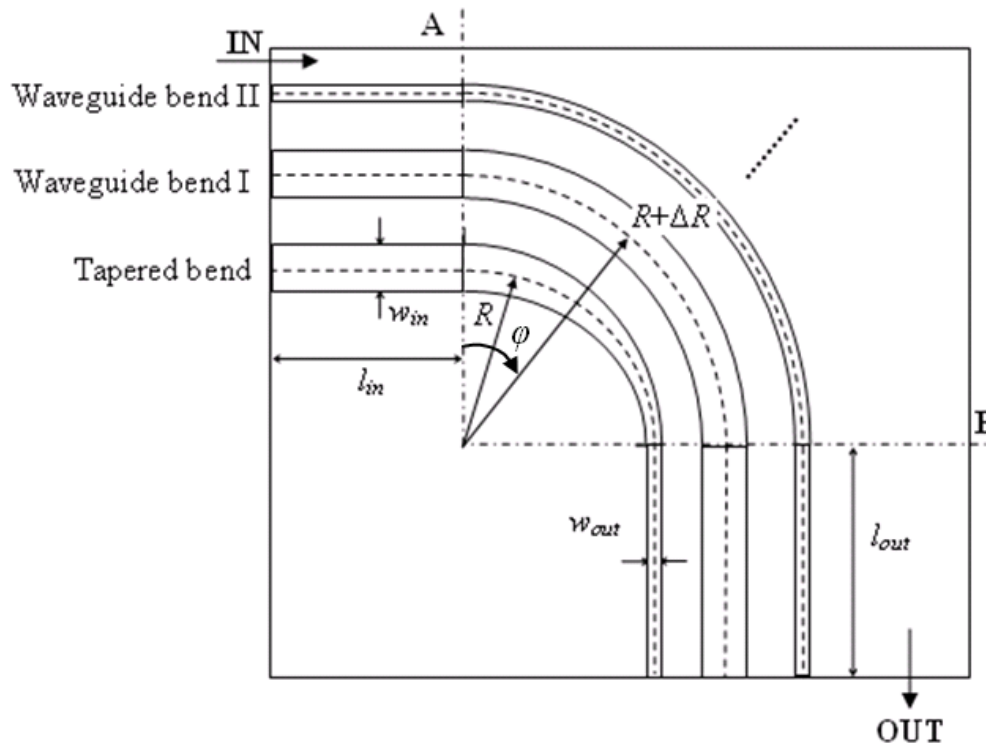


Light through a bent waveguide of $R = 5.5 \text{ mm} - 34.5 \text{ mm}$

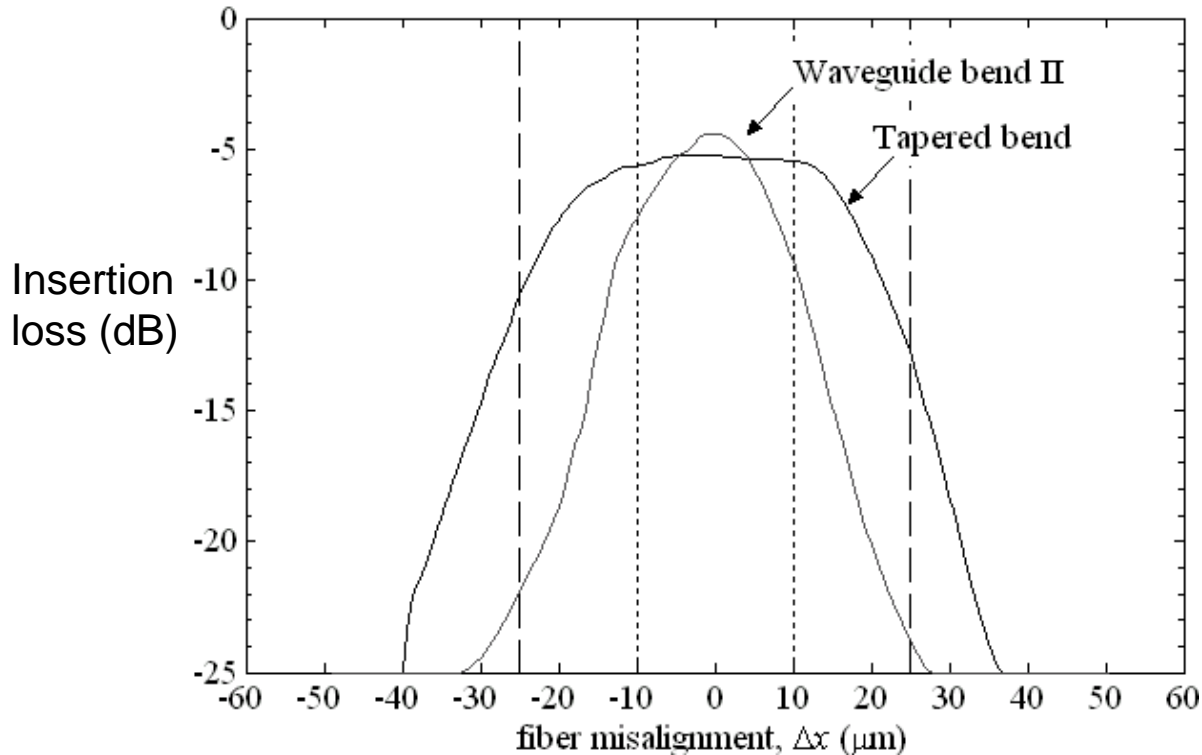
- Radius R , varied between $5.5 \text{ mm} < R < 35 \text{ mm}$, $\Delta R = 1 \text{ mm}$
- Light lost due to scattering, transition loss, bend loss, reflection and back-scattering
- Illuminated by a MM fiber with a red-laser.



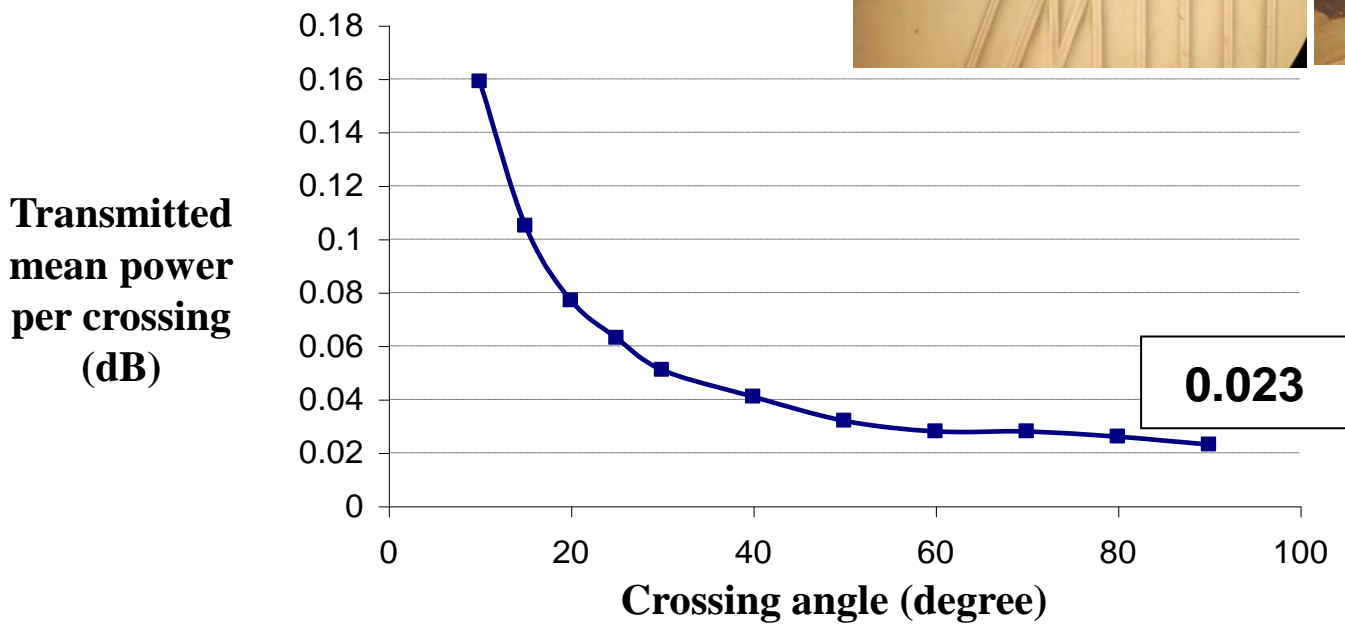
Width (μm)	Minimum Radius (mm)	Minimum Loss (dB)
50	13.5	0.74
75	15.3	0.91
100	17.7	1.18



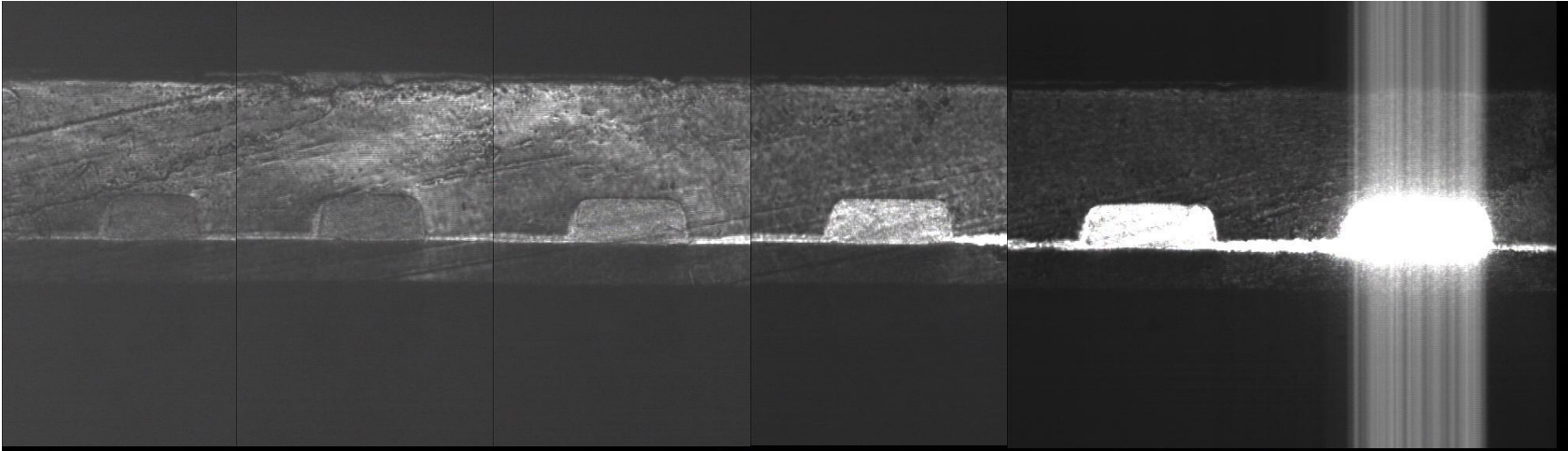
- ❑ The input section $w_{in} = 50 \mu\text{m}$, and its length $l_{in} = 11.5 \text{ mm}$
- ❑ The tapered bend transforms the waveguide width from w_{in} , to w_{out}
- ❑ The width of the tapered bends varies linearly along its length
- ❑ Output straight waveguide length $l_{out} = 24.5 \text{ mm}$.
- ❑ Output widths $w_{out} = 10 \mu\text{m}, 20 \mu\text{m}, 25 \mu\text{m}, 30 \mu\text{m}$ and $40 \mu\text{m}$



- ❑ Dashed lines correspond to the boundaries of the $w_{in} = 50 \mu\text{m}$ tapered bend
- ❑ Dotted lines correspond to the boundaries of the $20 \mu\text{m}$ bend
- ❑ Tapered bend has more misalignment tolerance for a slight loss penalty

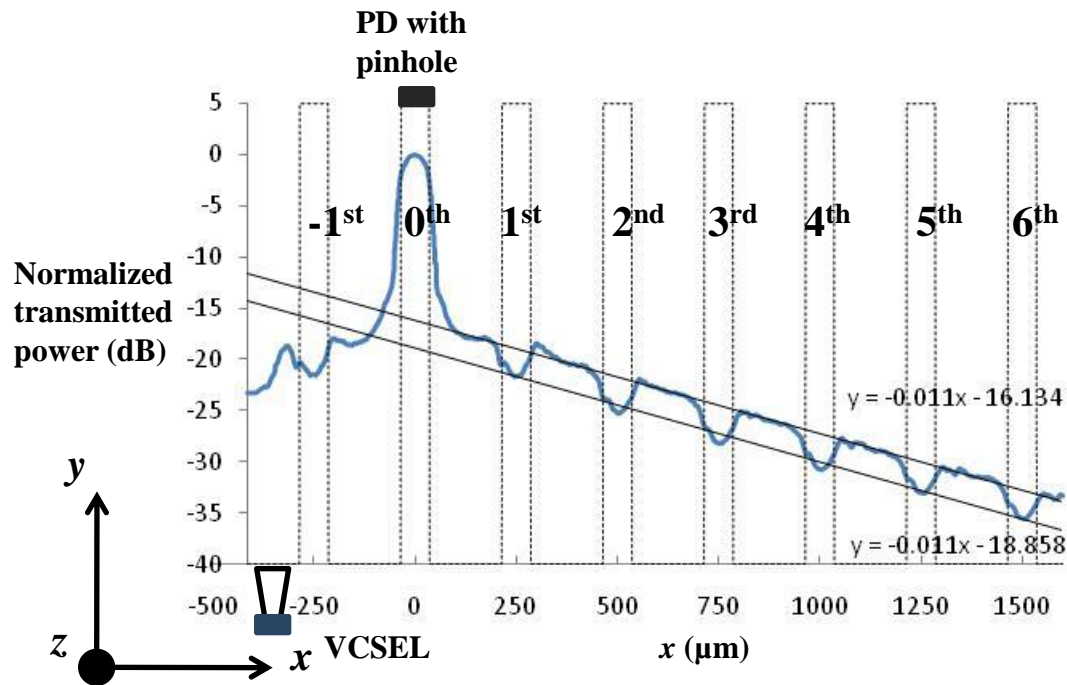


- Loss of 0.023 dB per 90 crossing consistent with other reports
- The loss per crossing (L_c) depends on crossing angle (θ), $L_c = 1.0779 \cdot \theta^{-0.8727}$.

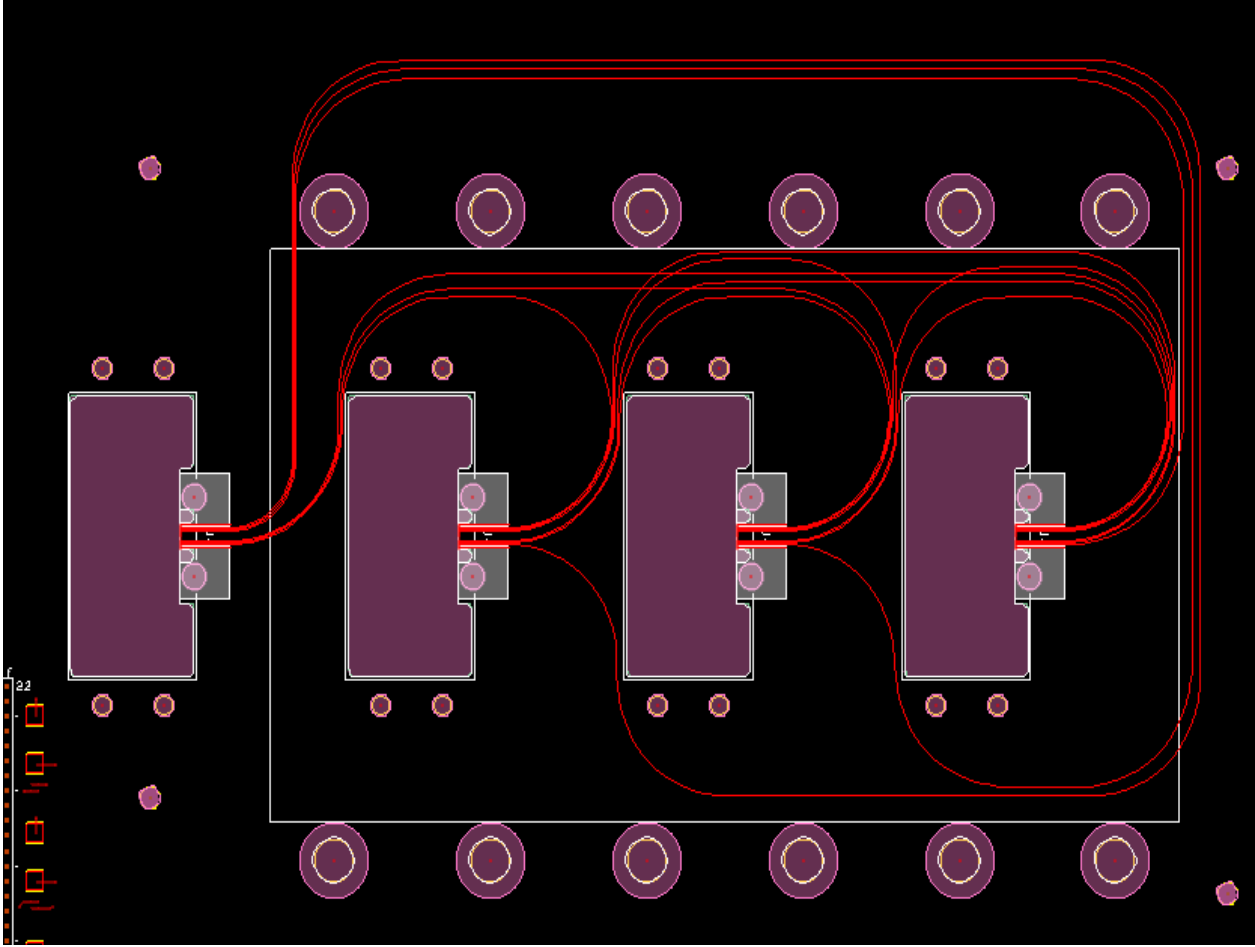


100 μm 110 μm 120 μm 130 μm 140 μm 150 μm

- ❑ Light launched from VCSEL imaged via a GRIN lens into 50 μm x 150 μm waveguide
- ❑ Photolithographically fabricated chirped with waveguide array
- ❑ Photomosaic with increased camera gain towards left



- ❑ 70 μm 70 μm waveguide cross sections
- ❑ Waveguide end facets diced but unpolished scatters light into cladding
- ❑ In the cladding power drops linearly at a rate of 0.011 dB/ μm
- ❑ Crosstalk reduced to -30 dB for waveguides 1 mm apart



Fully connected waveguide layout using design rules

- Papakonstantinou,I., et al., (2008). Low cost, precision, self-alignment technique for coupling laser and photodiode arrays to waveguide arrays. *IEEE Transactions on Advanced Packaging* . ISSN: 1521-3323
- Papakonstantinou,I., et al., (2008). Insertion Loss and Source Misalignment Tolerance in Multimode Tapered Waveguide Bends. *IEEE Photonics Technology Letters* 20(12), 1000-1002. ISSN: 1041-1135
- Papakonstantinou,I., et al., (2008). Optical 8-Channel, 10 Gb/s MT Pluggable Connector Alignment Technology for Precision Coupling of Laser and Photodiode Arrays to Polymer Waveguide Arrays for Optical Board-to-Board Interconnects. *ECTC, May 27-30, Florida, USA,*
- Selviah,D.R. (2008). Invited Conference Plenary Paper: Integrated Optical and Electronic PCB Manufacturing. *IEEE Workshop on Interconnections within High Speed Digital Systems, Santa Fe, USA, 18-21 May 2008, Santa Fe, New Mexico, USA:IEEE*
- Selviah,D.R. (2008), *UK Displays and Lighting, Korean Trade Visit, Department of Business, Enterprise and Regulatory Reform, 1.*
- Selviah,D.R., et al., (2008). Integrated Optical and Electronic Interconnect Printed Circuit Board Manufacturing. *Circuit World* 34(2), 21-26. ISSN: 0305-6120

- Selviah,D.R., (2008). Invited Author: Computational Modeling of Bound and Radiation Mode Optical Electromagnetic Fields in Multimode Dielectric Waveguides. *Progress In Electromagnetics Research Symposium PIERS 2008 in Cambridge, USA, 2-6 July, 2008*
- Selviah,D.R.(2008). *19th IEEE LEOS Workshop on High Speed Interconnections within Digital System, HSD '08, May 18th-21st, Santa Fe, New Mexico, USA*
- Selviah,D.R., et al., (2008). Innovative Optical and Electronic Interconnect Printed Circuit Board Manufacturing Research. *2nd Electronics System-Integration Technolgy Conference (ESTC) Greenwich, UK, 1st-4th September 2008,*
- Wang,K., et al., (2008). Photolithographically Manufactured Acrylate Multimode Optical Waveguide Loss Design Rules. *2nd Electronics System-Integration Technolgy Conference (ESTC) Greenwich, UK, 1st-4th September 2008,*
- Baghsiahi,H., et al., (2008). Photolithographically Manufactured Acrylate Multimode Optical Waveguide Misalignment Design. *2nd Electronics System-Integration Technolgy Conference (ESTC) Greenwich, UK, 1st-4th September 2008,*

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Supplemental Slides

HOW TO MAKE AN OPTICAL PCB

1. Deposit lower cladding
2. Cure
3. Deposit core
4. Align mask
5. Cure waveguides
6. Remove uncured material
7. Deposit upper cladding
8. Cure

